



Dosimetry with silicon pixel detectors

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Part I

Dosimetry with Si diodes

With reference to external photon beam radiotherapy

1. Introduction
2. Operating principle
3. Dosimetric performances (sensor specific)
4. Solutions to improve radiation hardness
5. Dosimetric performances (device specific)

Introduction

Advantages and drawbacks of Si dosemeters

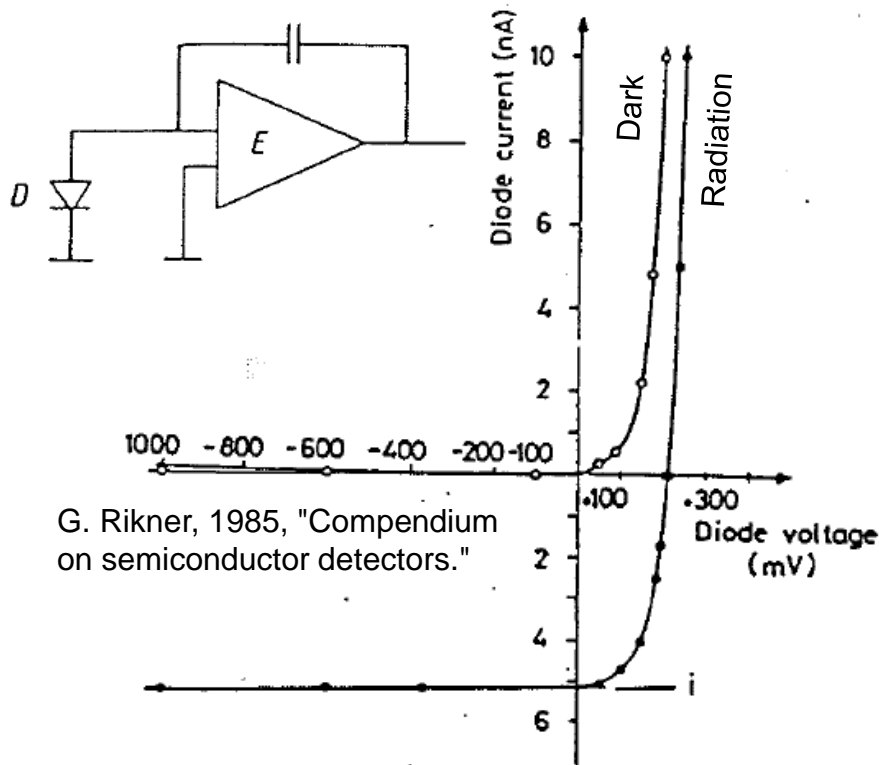
	Feature	Consequence
PRO	High specific sensitivity ($\sim 650\text{nC/mm}^3$)	Suitable for detectors with high spatial resolution
	Well developed (and cheap) manufacture technology	
	Photovoltaic mode (null bias)	Simplified design
CONS	Radiation Damage	Sensitivity drift with dose Dose rate linearity
	Not water equivalent ($Z=14$)	Energy dependence

Basic ideas are known since long; their exploitation still in progress...

See e.g. R. P. Parker et al, „Silicon PN junction surface-barrier detectors and their application to the dosimetry of X- and gamma-ray beams, Solid state and chemical radiation dosimetry in medicine and biology“, symposium proceedings, IAEA, 1967, p. 167.

Introduction

Readout scheme



G. Rikner, 1985, "Compendium on semiconductor detectors."

Features:

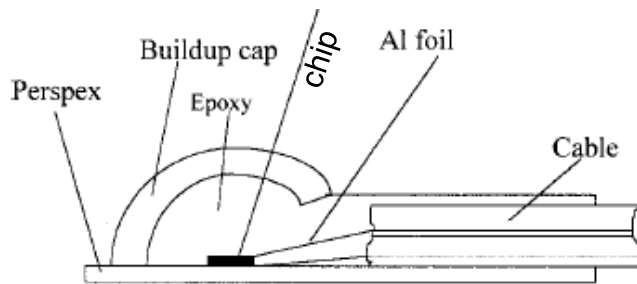
- "null bias" (to minimize leakage current; no concerns about signal strength and speed).
- DC coupling.
- Sampling time and reset fixed by electronics (usually $T \geq 10\text{ms}$).
- Only integrated charge is measured.
- Situation is different for "single event" detectors, where one typically has:
 - diode bias at full depletion (full collection and speed).
 - AC coupling (to get rid of reverse current).

Null bias simplifies everything (chip design, PCB layout, operation...)

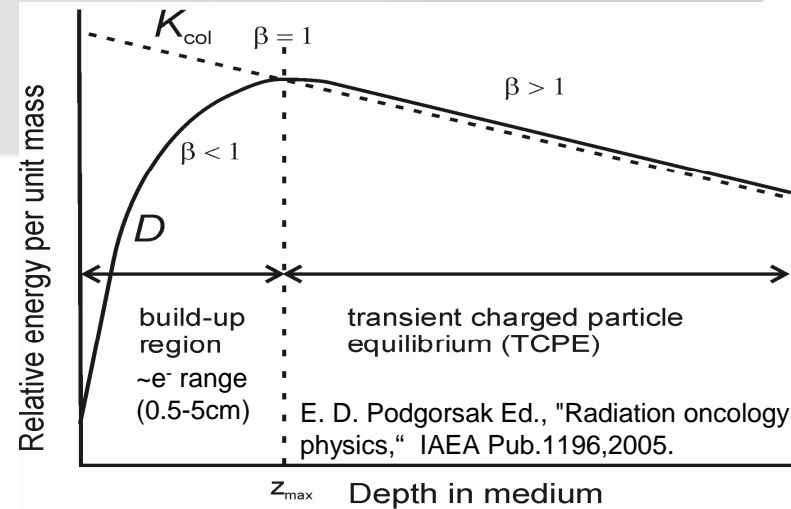
Introduction

Basic geometries for single diode detectors

“In-vivo detectors:” to be attached to patient body
 Buildup: “thicker & heavy” (e.g. Brass, Steel, W)



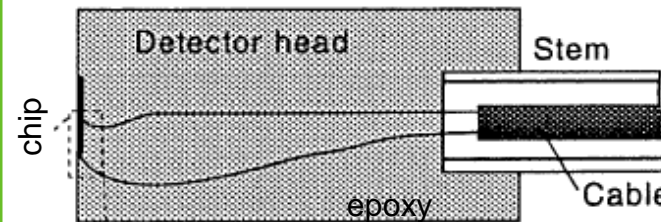
E.g. IBA EDP15



“Field detectors:” to characterize radiation fields
 Buildup: water equivalent, as thin as possible
 Additional buildup added by the user (H_2O or plastic)



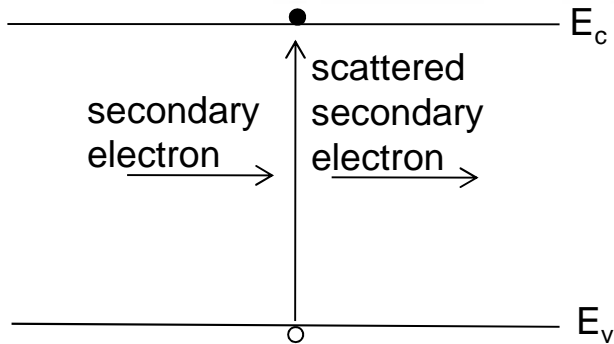
E.g. IBA EFD



Null bias: a guard is not needed!

Operating principle

Excess carrier generation



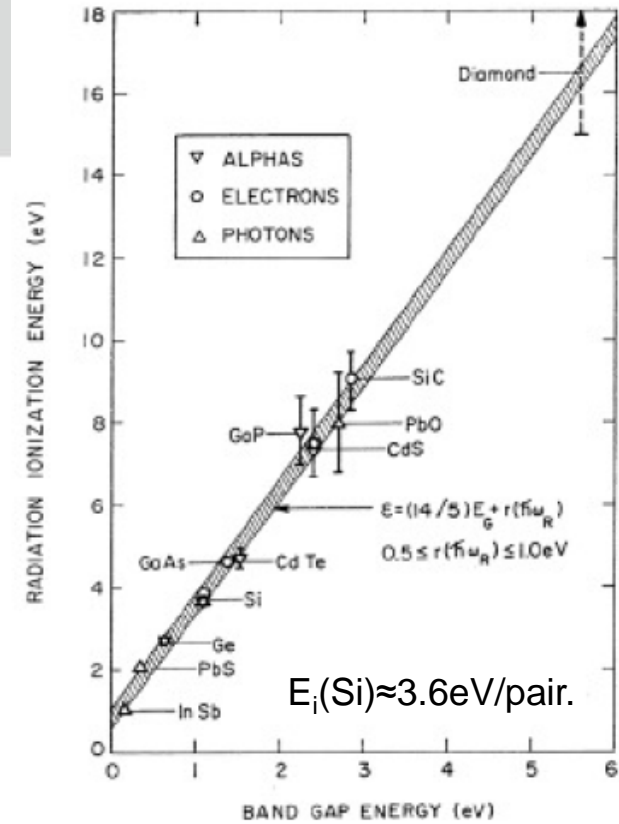
It gives high sensitivity!

$$G = R \rho_{Si} / E_i$$

$$s = \frac{Q}{D} = \frac{qG}{R} = \frac{q\rho_{Si}}{E_i} = 637 \frac{nC}{Gy \cdot mm^3}$$

G_i: carrier generation rate;
 R_i: dose rate;
 ρ_{Si}: Si density;
 E_i: mean ionization energy.

s: specific sensitivity
 Q: released charge;
 D: delivered dose;
 q: elementary charge



E_i(Si) ≈ 3.6 eV/pair.

E_i/E_{gap} constant (at fixed T) for many semiconductors under general conditions.



Operating principle

Carrier diffusion (I)

Assumptions:

- Excess carriers freely diffuse in the bulk.
- Diffusion length is limited by recombination.
- Minority carriers reaching depleted region edge, are swept by the field and generate a current.

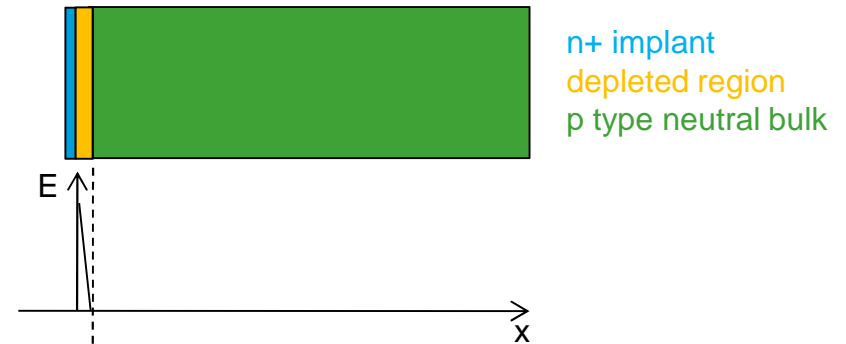
$$\frac{\partial^2 \Delta n}{\partial x^2} = \left(\frac{\Delta n}{\tau_e} - G \right) \frac{1}{D_e}, \quad \text{Diffusion equation}$$

$$D_e = \frac{kT}{q} \mu_e = 37.6 \text{ cm}^2 / \text{s}. \quad \text{Diffusivity (at 300K)}$$

Boundary condition (for a semi-infinite bulk):

$$\Delta n(0) = 0$$

i.e. all the electrons approaching the depleted region are promptly swept by electric field.



A simple model (any drift is ruled out) even if very useful to interpret experimental results

Operating principle

Carrier diffusion (II)

Solution of diffusion equation:

$$\Delta n = \frac{GL_e^2}{D_e} (1 - \exp(-x/L_e)).$$

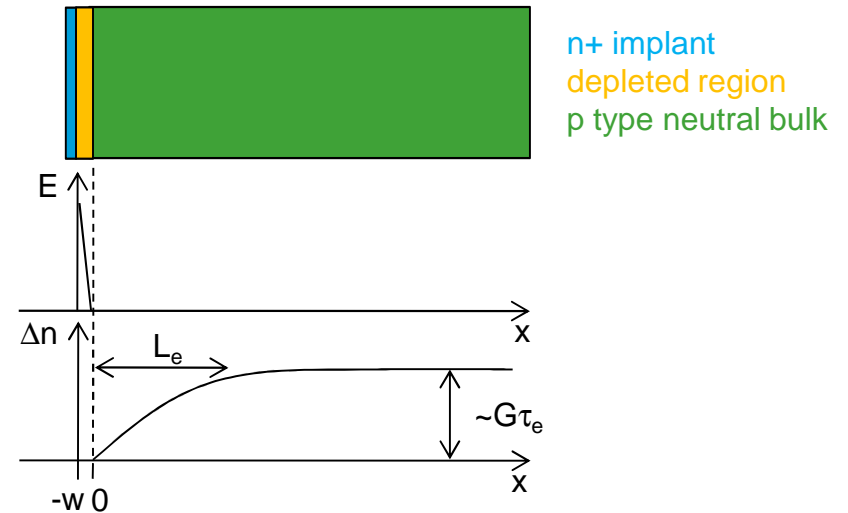
$$L_e^2 = \tau_e D_e.$$

$$j_e(x) = qD_e \frac{\partial \Delta n}{\partial x} = qL_e G e^{-x/L_e}$$

$$j = j_e(0) = qL_e G.$$

Rule of the thumb:

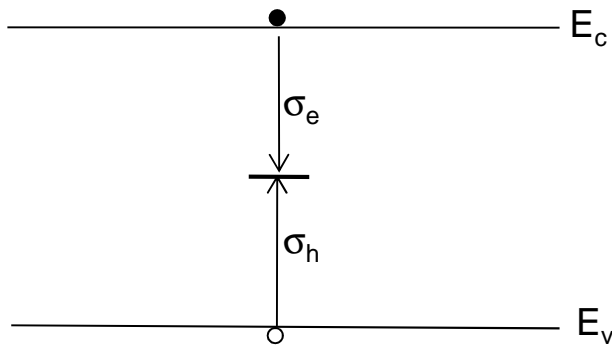
"All the minority carriers generated within a diffusion length from depleted region are collected."



j , total current density
 j_e , electrons current density
 q , elementary charge
 L_e , minority carriers diffusion length

Operating principle

Carrier recombination



Indirect recombination via midgap levels is dominant in silicon.

It is a 2 steps process:
capture e, then capture h,
or viceversa.

Shi J., Simon W. E.,
2003, Med. Phys. 30, 2509-19.
Shokley W., Read W. T. jr.,
1952, Phys. Rev., 87, 835-42.

$$\tau'_e \approx \tau_e \left(1 + \frac{\tau_h + \tau_e}{\tau_e} \cdot \frac{\Delta n}{p_0} \right) \approx \left(1 + \frac{(\tau_h + \tau_e) G \rho_{Si}}{p_0 E_i} R \right)$$

$\tau_{e/h}$, carriers lifetime;
 Δn , excess carriers concentration;
 p_0 , majority carriers equilibrium conc.

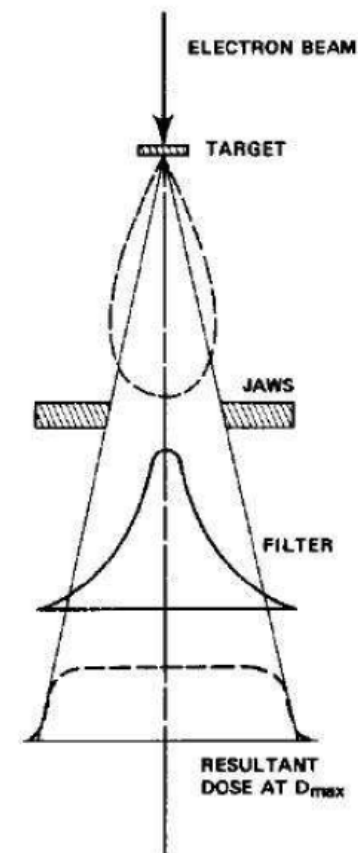
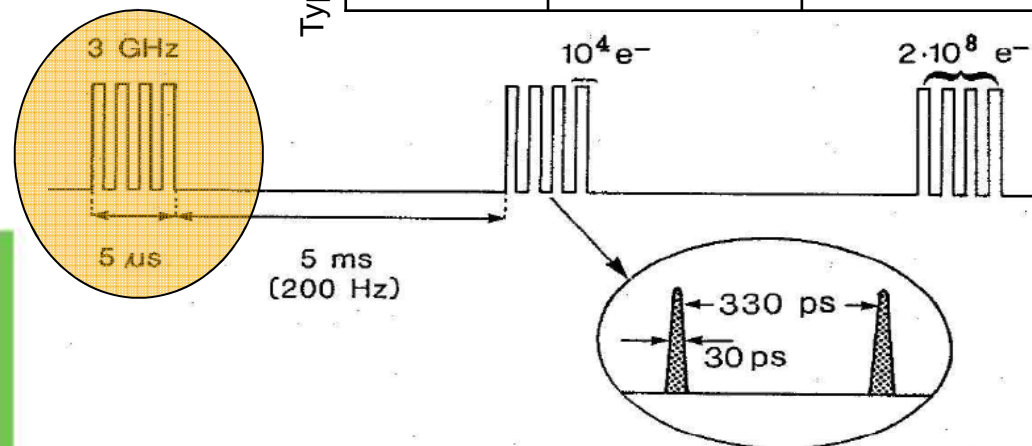
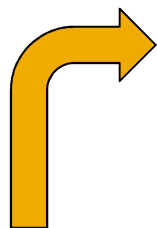
$$\tau_{e/h} = \frac{1}{\sigma_{e/h} v_{e/h} N_t}$$

$\sigma_{e/h}$, center capture cross sections;
 $v_{e/h}$, carriers thermal velocity;
 N_t , center concentration.

Dosimetric performances (sensor specific)

Dose rate dependence: context

Typical Macro-pulse parameter	Beam quality	4-18MV X	With target	
		4-18MeV e ⁻	No target	
	PRF	50-400Hz		
Max Dose rate		6Gy/min	Flattened	X rays isocenter
		20Gy/min	Unflattened	
Dose per pulse		0.1-0.5mGy	flattened	X rays
		0.4-2mGy	Unflattened	Depending on beam quality and SDD



Dosimetric performances (sensor specific)

Dose rate dependence: basic theory

Sensitivity per unit area of the diode:

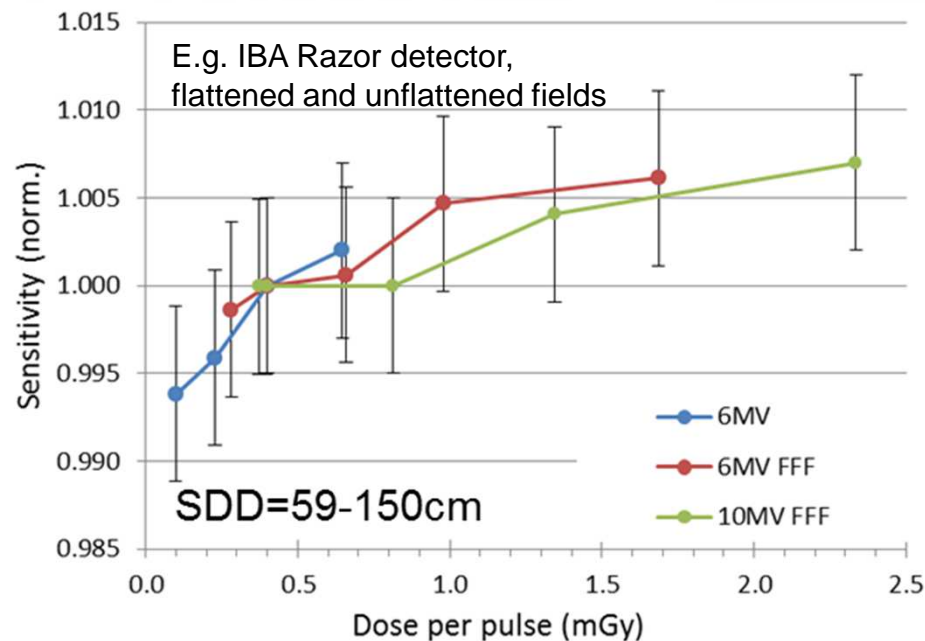
$$\frac{S}{A} = \frac{j}{R} = sL_e = \frac{q\rho_{Si}}{E_i} L_e.$$

$$\frac{S}{A} \approx \frac{q\rho_{Si}}{E_i} \sqrt{D_e \tau_e \left(1 + \frac{(\tau_h + \tau_e) G \rho_{Si}}{p_0 E_i} R \right)}$$

Dose rate non-linearity,
due to traps saturation.

Dose rate linearity is improved by:

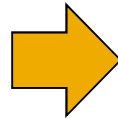
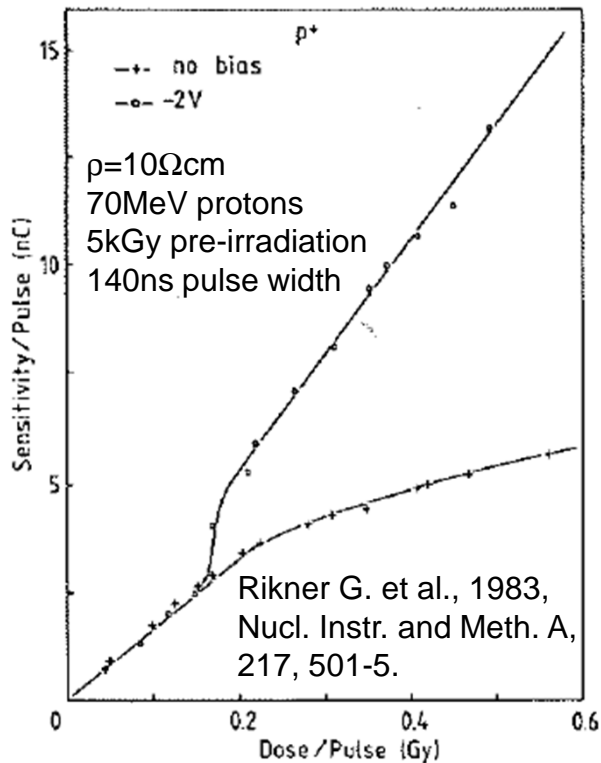
- high doping (i.e. high p_0);
- short lifetime.



Practically: this effect is seen only with pulsed radiation
(very high instantaneous dose rate)

Dosimetric performances (sensor specific)

Dose rate dependence: an extreme case



$$p_{p0} = \frac{1}{q\mu_h\rho} = 1.3 \cdot 10^{15} \text{ cm}^{-3},$$

$$\Delta n \approx \frac{GL_e^2}{D_e} = \frac{R\rho_{Si}L_e^2}{E_i D_e} \approx 5.5 \cdot 10^{15} \text{ cm}^{-3}, \text{ (at 0.2 Gy/pulse)}$$

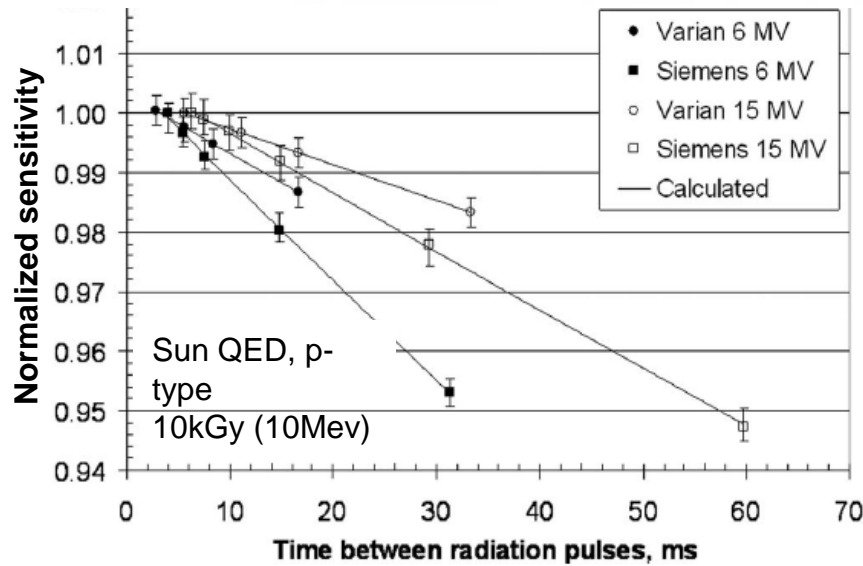
Sensitivity saturates when the excess carriers concentration is comparable to doping level.

In this case the junction electric field is heavily modified.

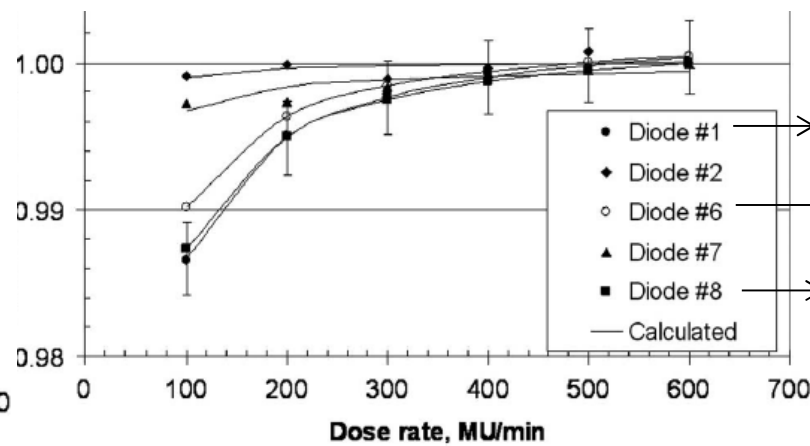
Dose rate beyond the range of clinical applications.

Dosimetric performances (sensor specific)

Dose rate dependence: PRF related effects



P. A. Jursinic, Med. Phys. 40 (2) 2013, 021720-1



Sun QED, p-type, 10kGy (10Mev)
 Sun Edge, n-type, Pt doped
 Sun Mapcheck, n-type, Pt doped

- Observed in few detectors only
- Sensitivity decrease at low dose rate, more evident at low dose per pulse
- Proposed explanation: Release from traps slower than $1/PRF$

Dosimetric performances (sensor specific)

Sensitivity vs dose: basic theory

$$\frac{S}{A} \approx \frac{q\rho_{Si}}{E_i} \sqrt{D_e \tau_e \left(1 + \frac{(\tau_h + \tau_e) G \rho_{Si}}{p_0 E_i} R \right)}$$

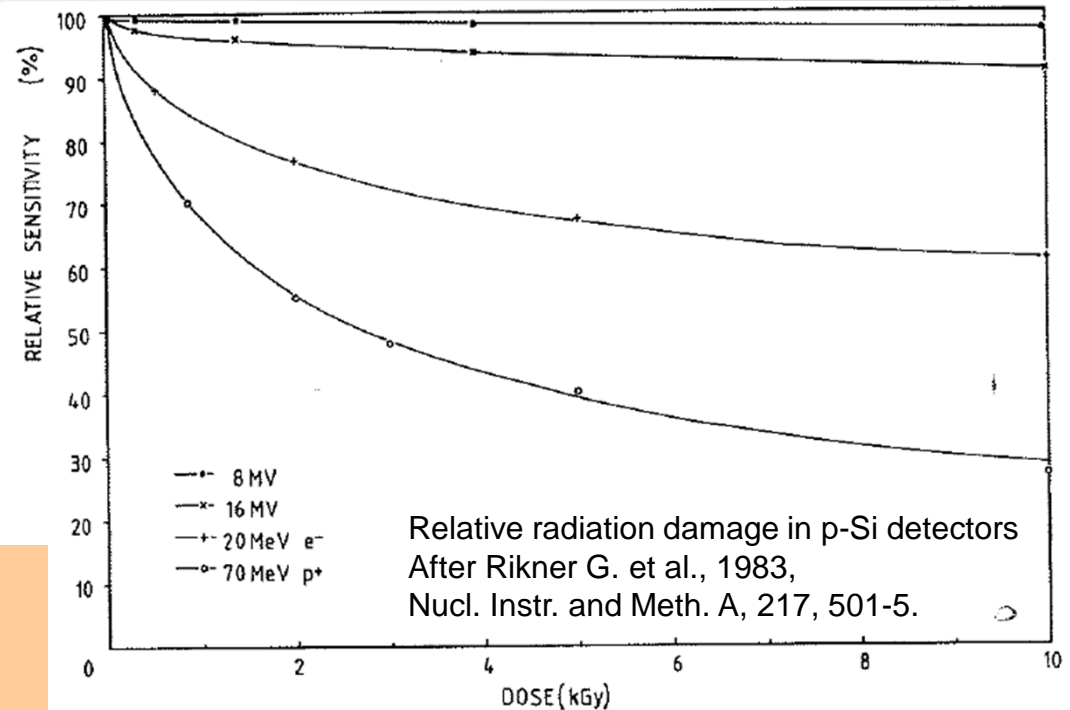
If a single trap dominated,
Neglecting R-related term

$$\frac{S}{A} = \frac{q\rho_{Si}}{E_i} \sqrt{\frac{D_e}{\sigma_e v_e N_t}} \propto N_t^{-1/2}.$$

N_t grows with Dose, thus τ_e and L_e decrease

Consequences:

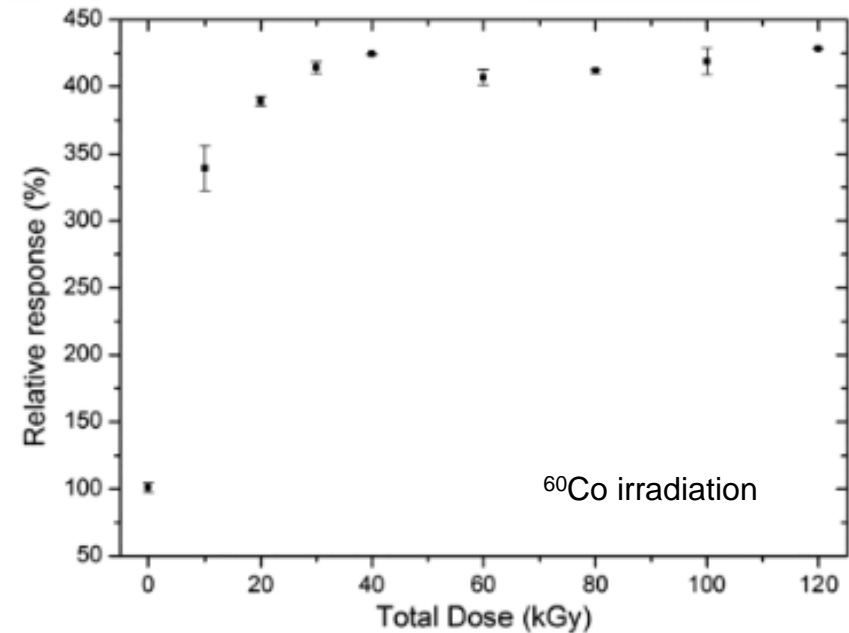
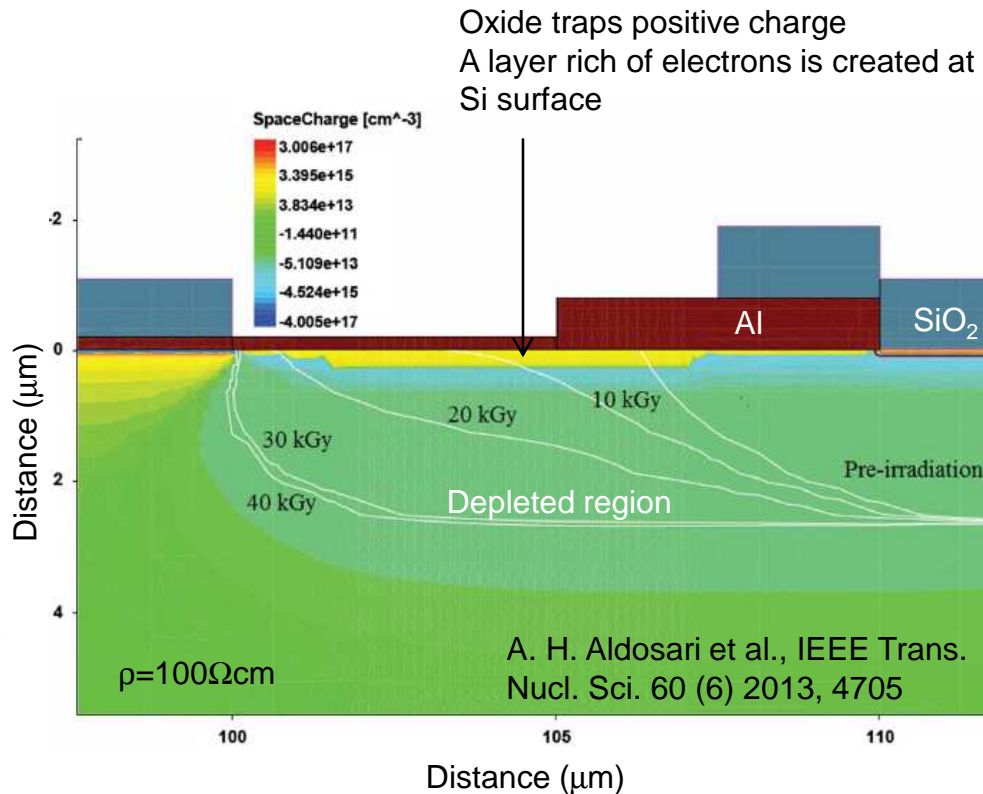
- decrease of sensitivity S during use
- need of periodic recalibration.



Essential for arrays: central pixel receive higher dose!!
Annealing play a big role!!

Dosimetric performances (sensor specific)

Sensitivity vs dose: oxide related effects



- Relevant for p-type Si only
- Determines sensitivity increase
- Visible only after low energy (e.g. ⁶⁰Co) irradiation
- Otherwise bulk damage dominates

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Dosimetric performances (sensor specific)

Temperature dependence (I)

Important for in-vivo applications.
Accordingly to the outlined theory:

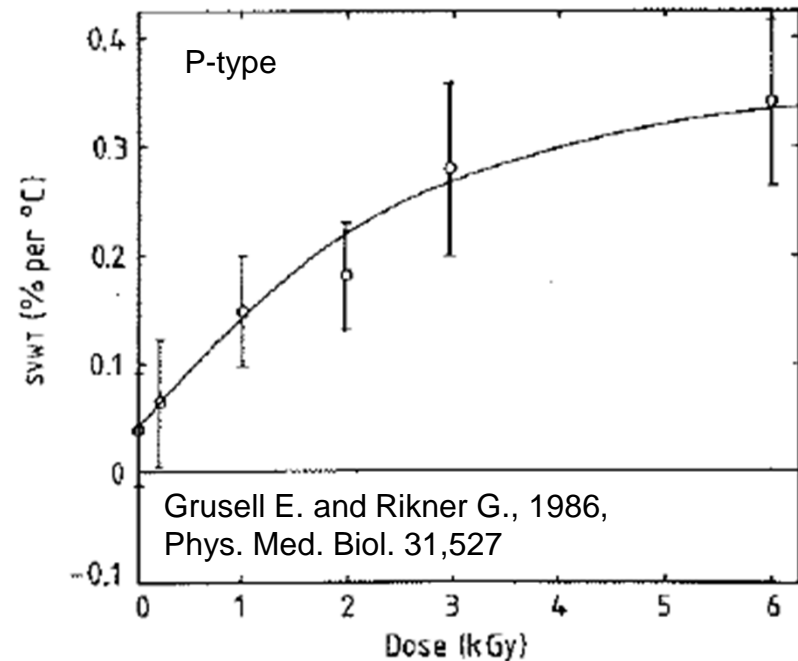
$$\mu_e \propto T^\gamma, \gamma \approx -2,$$

$$svwt = \frac{1}{S} \frac{dS}{dT} = \left(\frac{1}{4} + \frac{\gamma}{2} \right) \frac{1}{T} \approx -0.3\% \quad (@ 300K)$$

Actually, this is not the case...

- svwt is usually positive
- svwt is influenced by irradiation.
- assumption of a single dominant deep level is probably not adequate

Diodes with most pronounced dose-per-pulse dependence exhibit the highest svwt
(Van Dam, Radiother. Oncol. 19, 245,1990)



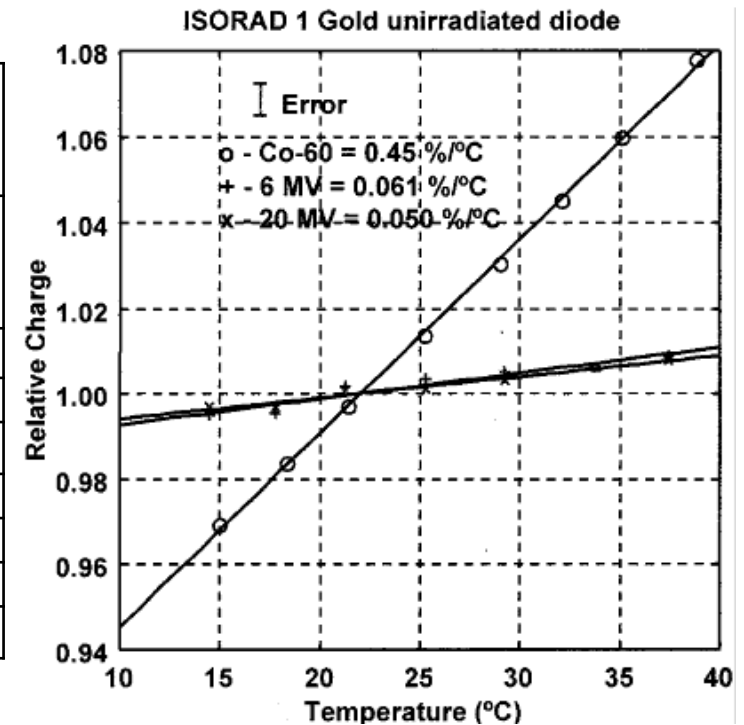
Dosimetric performances (sensor specific)

Temperature dependence (II)

All diodes without Pt doping

Model	Type	ρ (Ωcm)	Pre-irradiation Dose 10MeV e- (kGy)	Temp. Coeff. (%/K)		
				^{60}Co	6MV	15-20MeV
EDP10	p	0.2	8	0.36	0.38	0.33
EDP30	p	0.2	8	0.39	0.36	0.34
Isorad Gold	n	35	none	0.16-0.45	0.05-0.1	0.05-0.1
Isorad Red	n	35	10	0.37	0.22	0.21
QED Blue	p	0.8	10	0.30	0.30	0.31
QED Red	p	0.8	10	0.29	0.29	0.29
QED unirradiated	p		None	0.34	0.25	0.27

1. In most cases $\text{swt}=0.2-0.4\%/K$
2. Variation with beam energy only in unirradiated diodes

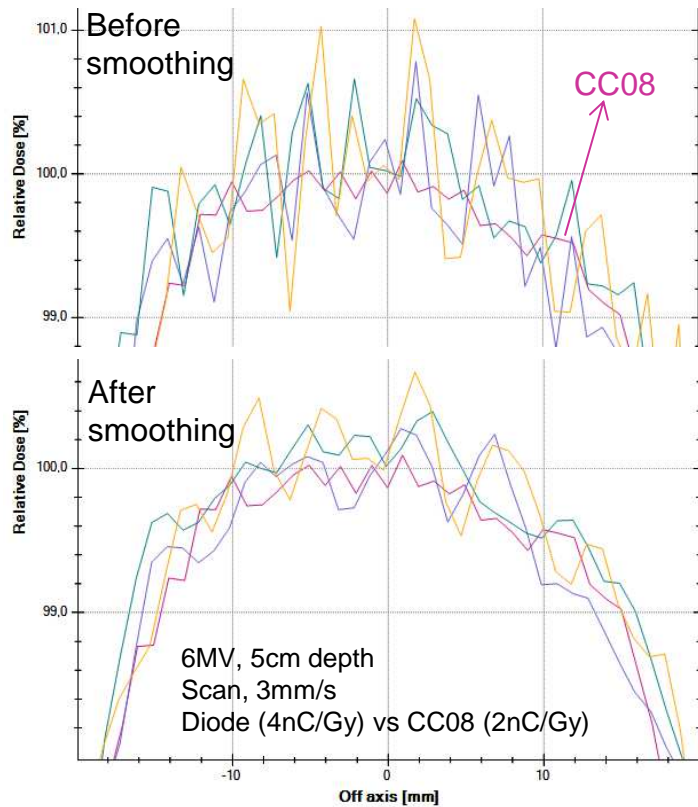


Saini A. S. and Zhu T. C, 2002,
Med. Phys. 29, 622

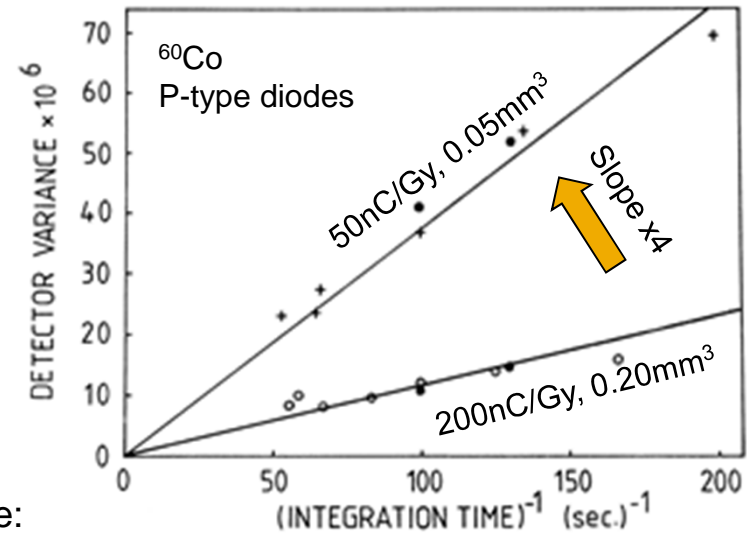
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Dosimetric performances (sensor specific)

Quantum noise



Rikner, G., et al. 1984. Acta Rad. Oncol., 23, 471.



Quantum noise:

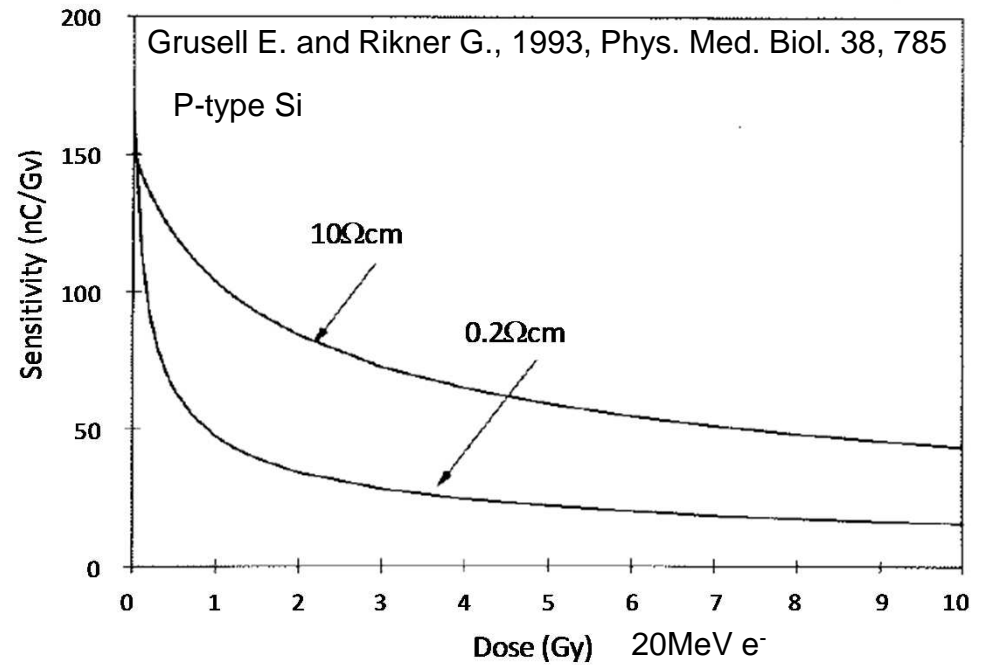
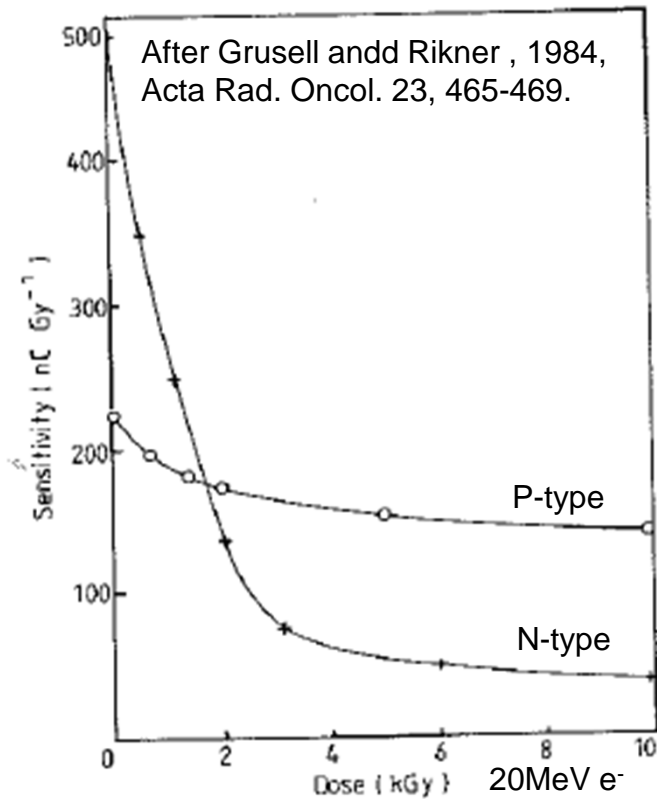
$$\frac{\sigma^2}{D^2} = \frac{1}{N} \left(1 + \frac{\sigma_F^2}{\langle z \rangle_F^2} \right)$$

Smaller detectors may exhibit a „larger“ noise, in spite of absolute sensitivity

Important for scans with small diodes!

Solutions to improve radiation hardness

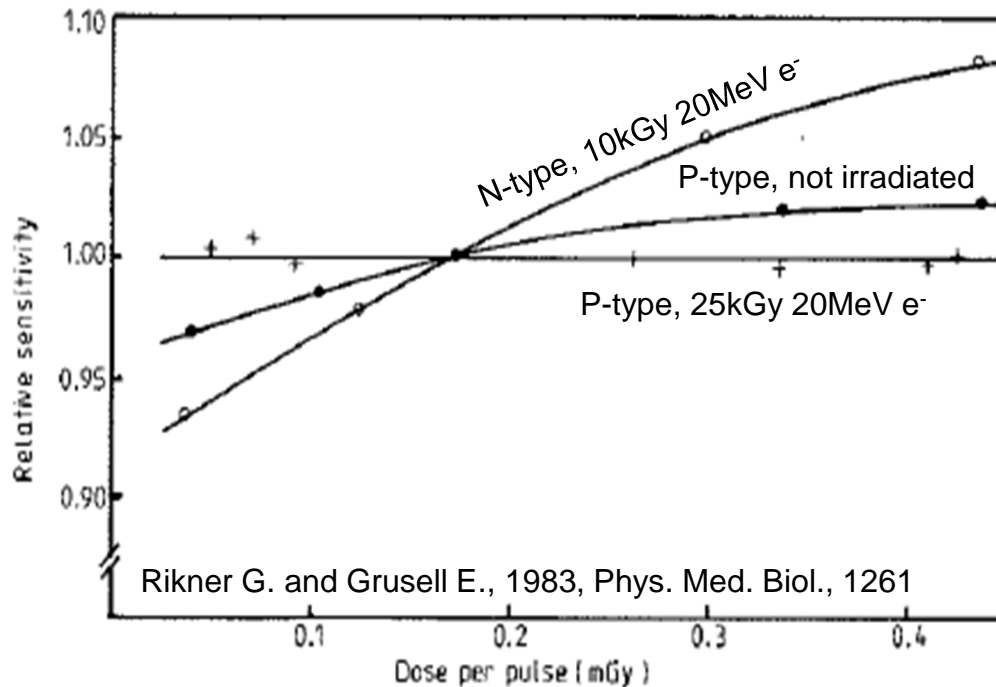
Recipe 1: preirradiation...



Since S decreases with dose ($S \sim N_t^{-0.5}$),
pre-irradiation reduces dS/dD slope

Solutions to improve radiation hardness

Recipe 1: ...p-type...



Dominant center produced by radiation (e⁻):

$$\sigma_e = 1.62 \times 10^{-16} \text{cm}^2,$$

$$\sigma_h = 8.66 \times 10^{-16} \text{cm}^2.$$

For this center it is easier to capture holes!
Saturation is prevented if minority carriers are electrons:

$$\frac{\Delta \tau_e^{(rel)}}{\Delta \tau_h^{(rel)}} = \frac{\tau_h}{\tau_e} = \sqrt{\frac{m_h^*}{m_e^*} \left(\frac{\sigma_e}{\sigma_h} \right)} = \sqrt{\frac{0.38}{0.26} \frac{1.62}{8.66}} = 0.23,$$

$$\Delta \tau^{(rel)} = \frac{1}{S} \frac{dS}{dR}.$$

Shi J., Simon W. E., 2003, Med. Phys. 30, 2509
and cited refs.

Solutions to improve radiation hardness

Recipe 1: ...low resistivity.

Use of low resistivity improves recombination, as expected.
Even the effect of neutron-contaminated beams is negligible.

Table: "Φ factor" for diodes of two resistivities, at different pre-irradiation levels.

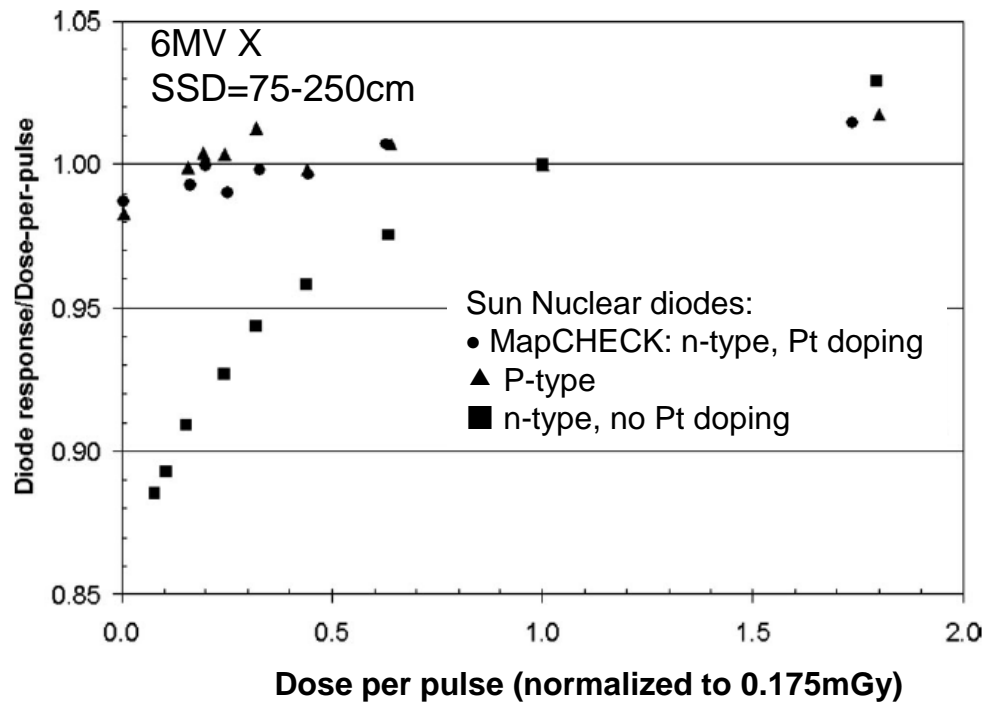
Detector type	Pre-irradiation Dose (kGy)	Pre-irradiation Beam quality			
		8MV	21MV	20MeV e ⁻	70MeV p ⁺
10Ωcm	0	1.00	1.00	1.00	1.00
	3	1.0	0.96	0.97	0.95
	10			0.98	
	25			0.99	0.92
0.2Ωcm	0	1.00	1.00	1.00	1.00
	3	1.00	1.00		
	5			1.00	1.00
	10			1.00	
	50	1.00	1.00		1.00

Grusell E. and Rikner G., 1993, Phys. Med. Biol. 38, 785-792.

$$\Phi = \frac{S_{Si}(highR)}{S_{IC}(highR)} / \frac{S_{Si}(lowR)}{S_{IC}(lowR)}$$

Solutions to improve radiation hardness

Recipe 2: Pt doping



Pt introduces a recombination level at:

$$E_V + 0.42\text{eV},$$
$$\sigma_h = 2.7 \times 10^{-12} \text{cm}^2$$
$$\sigma_e = 3.2 \times 10^{-14} \text{cm}^2.$$

Large σ are effective in reducing $\tau_{e/h}$.

If center concentration is high enough:

- it dominates against radiation induced centers (S independent on dose);
- traps saturation cannot be reached
- (no dose rate dependence).

Jursinic P. A. and Nelms B. E., 2003, Med. Phys. 30, 870.
Baliga, Sun, 1977, IEEE Trans. Electron Devices 24, 685

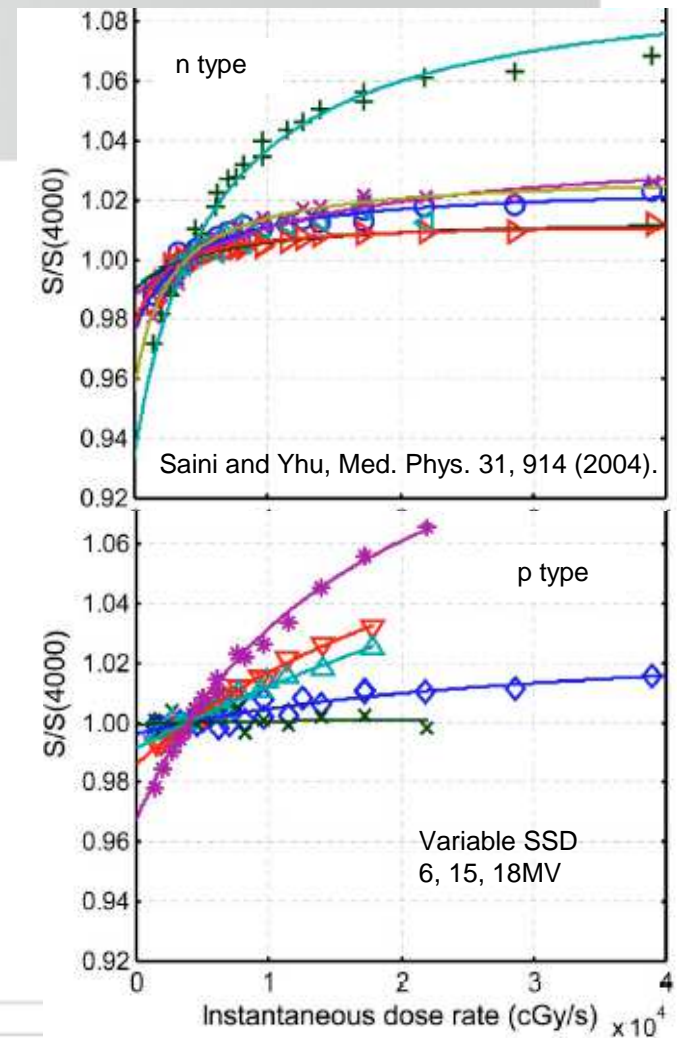
Solutions to improve radiation hardness

Comparison of commercial detectors

	Manufacture	Model	Type	Pt	ρ (Ωcm)	Preirradiation	
						Dose (kGy)	Energy (MeV)
◁	Nuclear Ass.	Veridose Green	n	yes	NA	8	10
◇	Scanditronix	EDP10	p	no	0.2	8	10
×	Scanditronix	EDP20	p	no	0.2	confidential	
○	Sun Nuclear	Isorad Gold	n	no	35	none	
+	Sun Nuclear	Isorad Red	n	no	35	10	3
*	Sun Nuclear	Isorad-p Red	p	no	0.8	10	10
▷	Sun Nuclear	Isorad-3 Gold	n	yes	10	none	
×	Sun Nuclear	QED Red	n	yes	10	none	
▽	Sun Nuclear	QED Blue	p	no	0.8	10	10
△	Sun Nuclear	QED Red	p	no	0.8	10	10

Low dose rate dependency and reproducibility is obtained with:

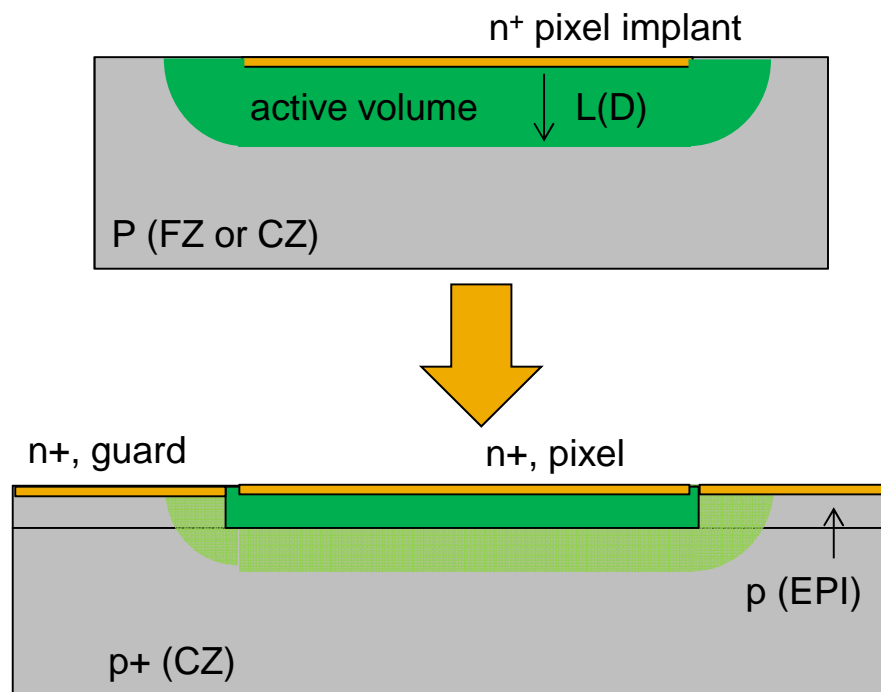
- p type, pre-irradiated, low resistivity;
- Pt doping.



Solutions to improve radiation hardness

Recipe 3: Epitaxial guarded diodes (I)

Example: p-type substrate



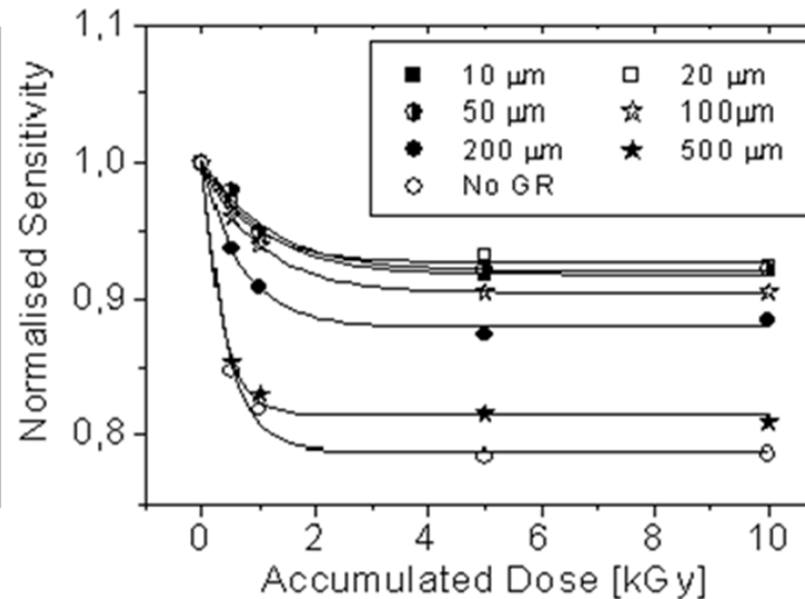
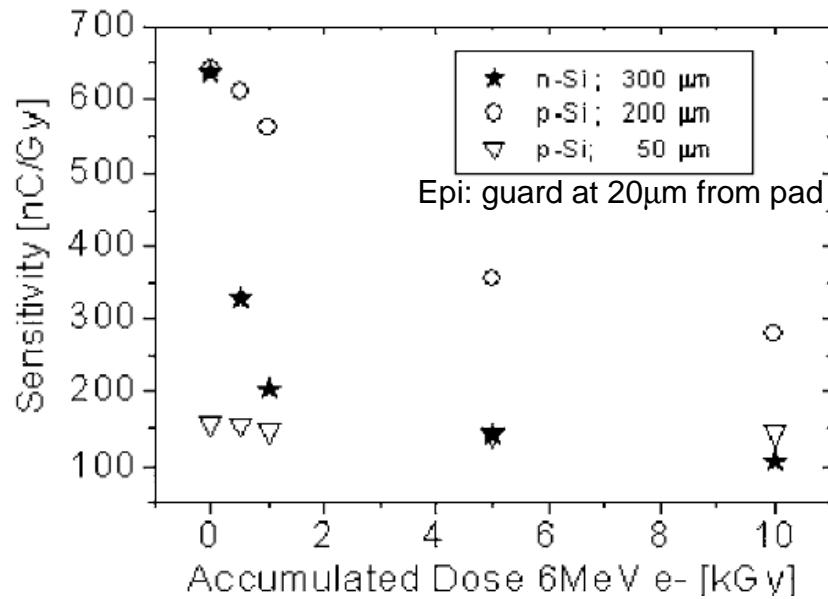
- e⁻ generated under the guard: collected by the guard
- e⁻ generated in the substrate: recombine (due to high doping)

Active volume is geometrically defined!

M. Bruzzi et al., Appl. Phys. Lett., 90 (2007) 172109 1-3.

Solutions to improve radiation hardness

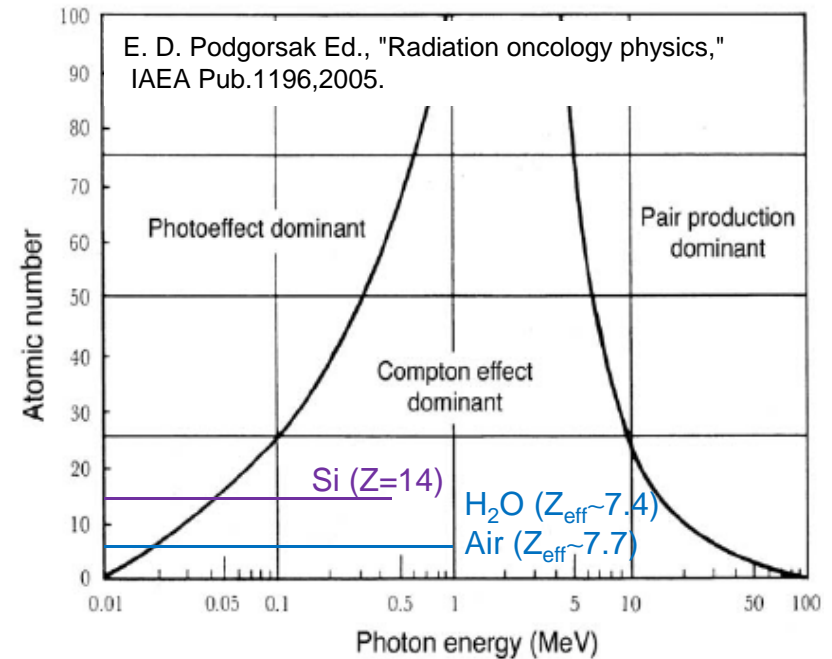
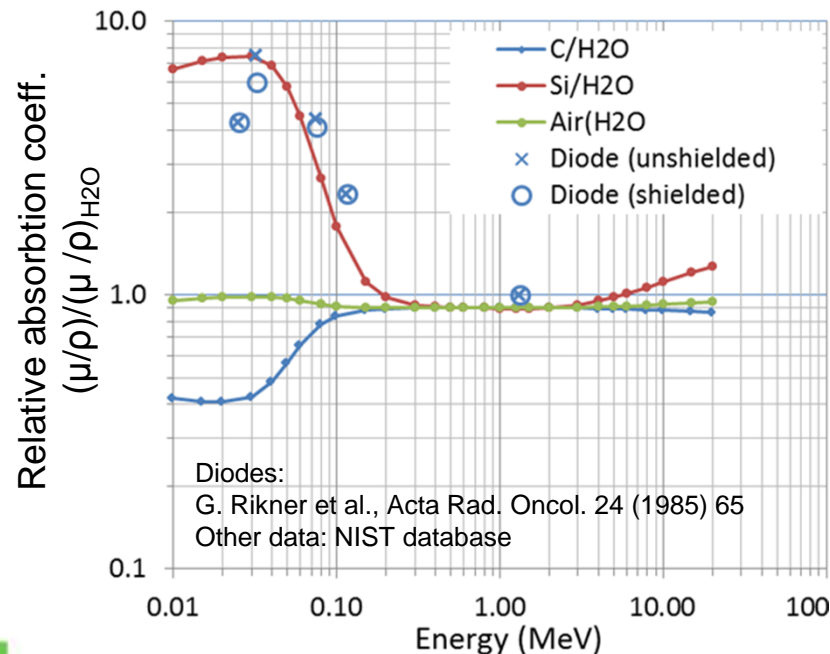
Recipe 3: Epitaxial guarded diodes (II)



M. Bruzzi et al., Appl. Phys. Lett., 90 (2007) 172109 1-3.

Dosimetric performances (Device specific)

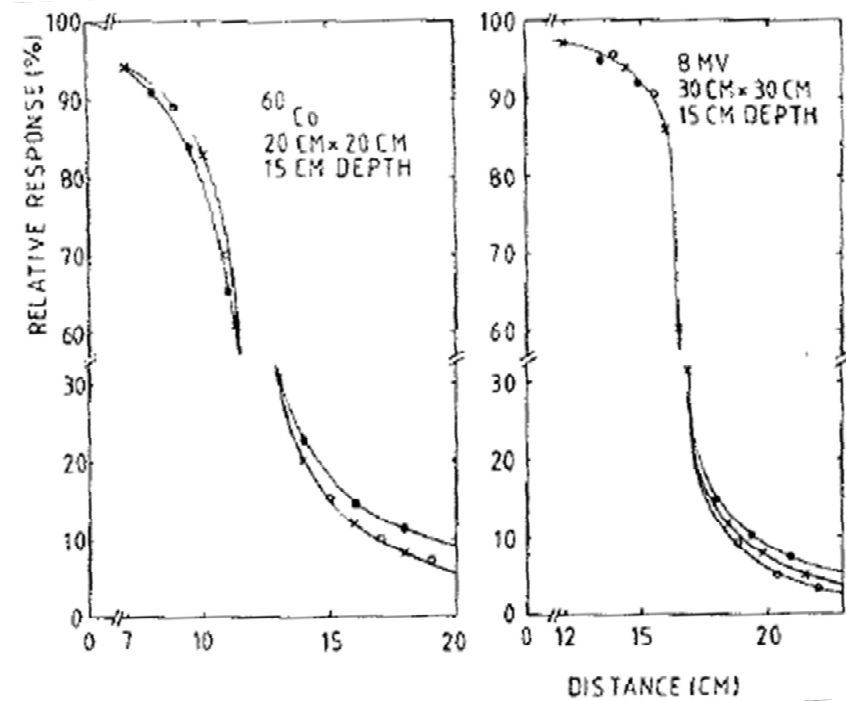
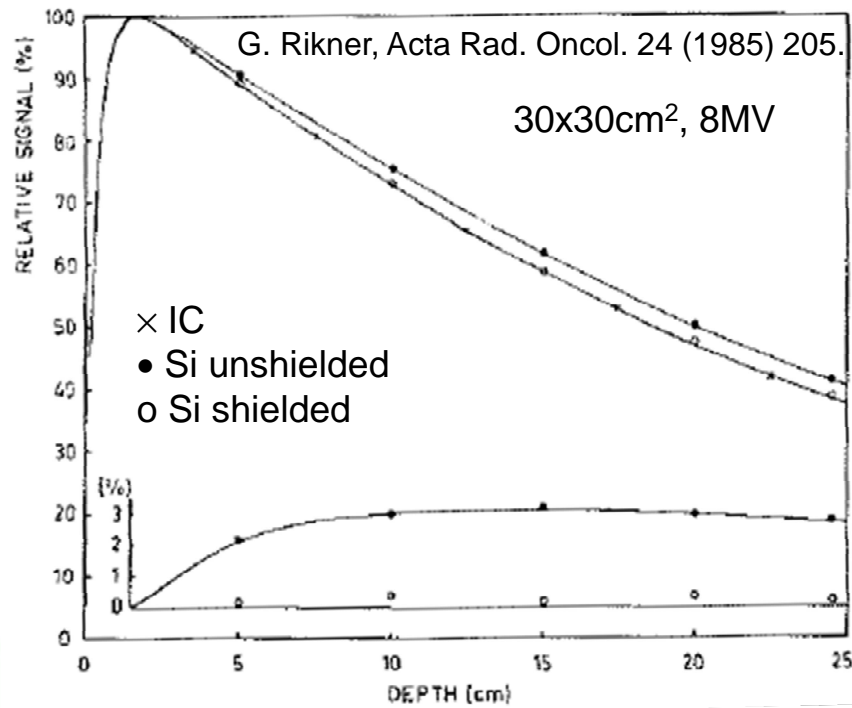
Energy dependence: origin



Si over-responds with respect to ionization chambers in conditions of high scattering
 Due to excess of photoelectric effect with respect to air and water
 Can be mitigated with a shield (e.g. Tungsten), absorbing low energy photons

Dosimetric performances (Device specific)

Energy dependence: effects on measurements

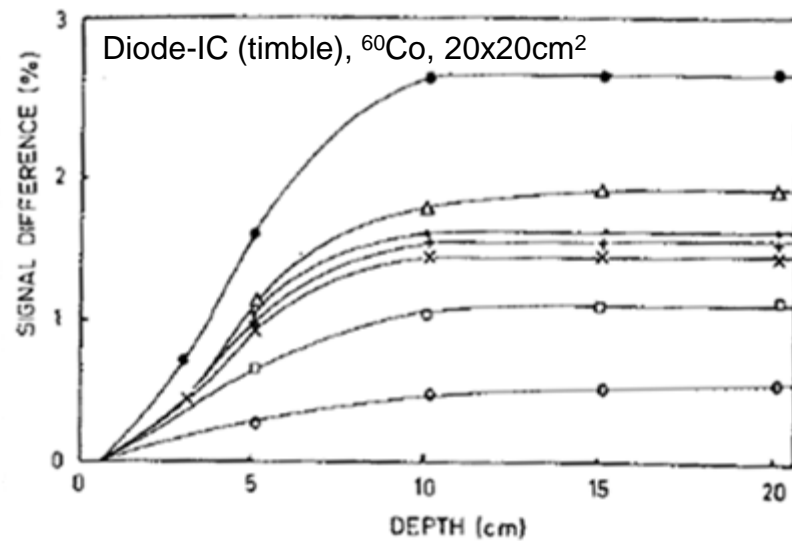


Overresponse is higher in depth, with large field sizes, at low energy

Dosimetric performances (Device specific)

Energy dependence: shield design

Rikner G. and Grusell E, 1985, Acta Rad. Oncol., 24, 65.

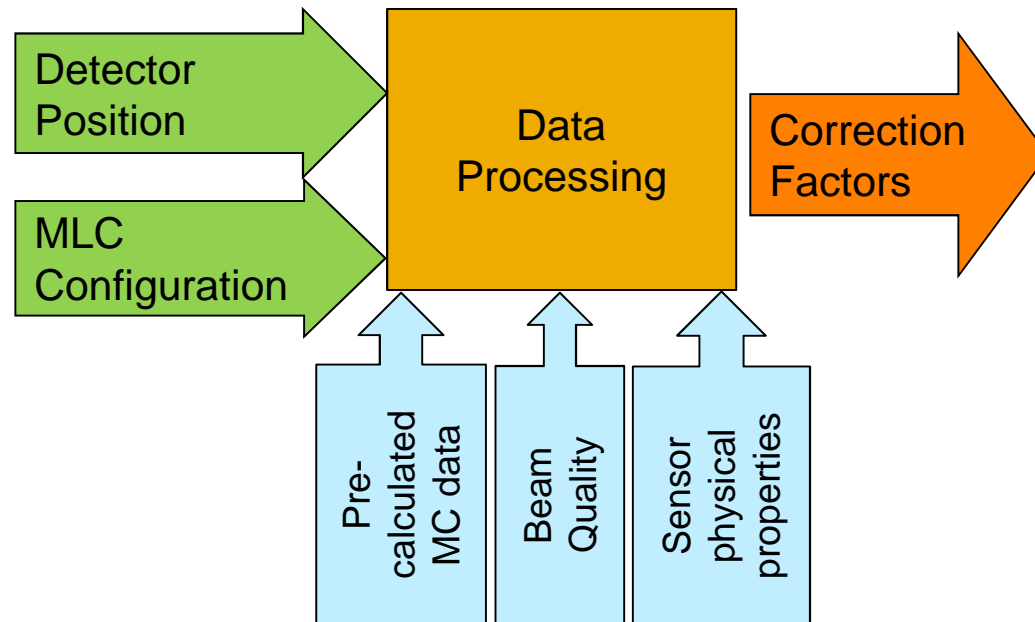


	Filter
•	none
△	0.5g/cm ² Pb, 2mm cylinder
·	0.5g/cm ² Pb, 6mm cylinder
+	0.5g/cm ² Pb, 15mm cylinder
□	0.5g/cm ² Pb, 15mm cylinder
×	1mm disk behind
○	1.0g/cm ² W+epoxy behind

- A large improvement is obtained by shielding the chip from low energy backscattering
- Shielded diodes shall be used only when necessary (sub-optimal for small fields and electrons)

Dosimetric performances (device specific)

Energy dependence: software correction (I)



First-order calculation:

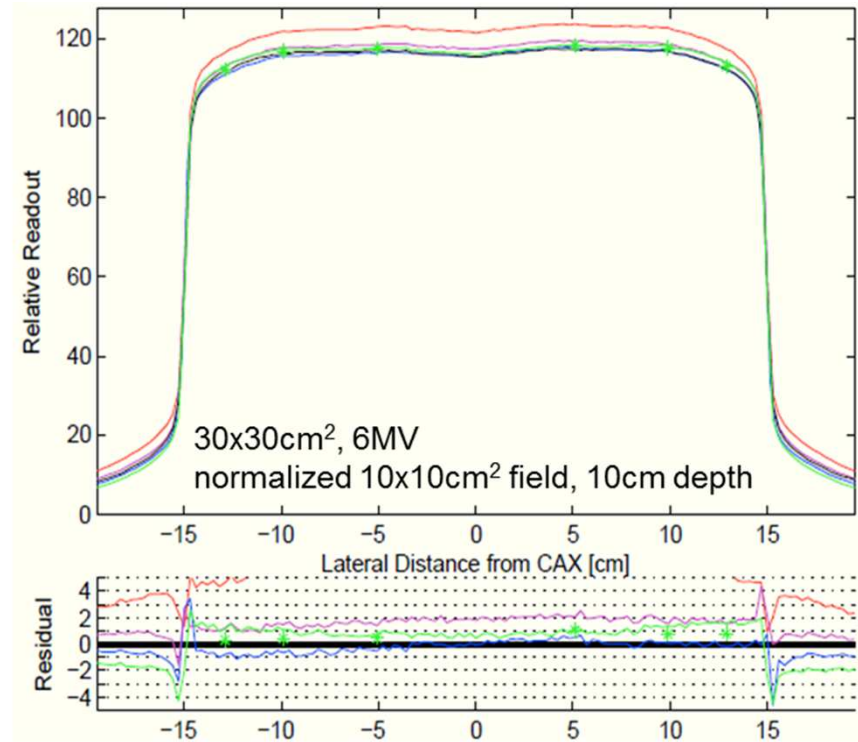
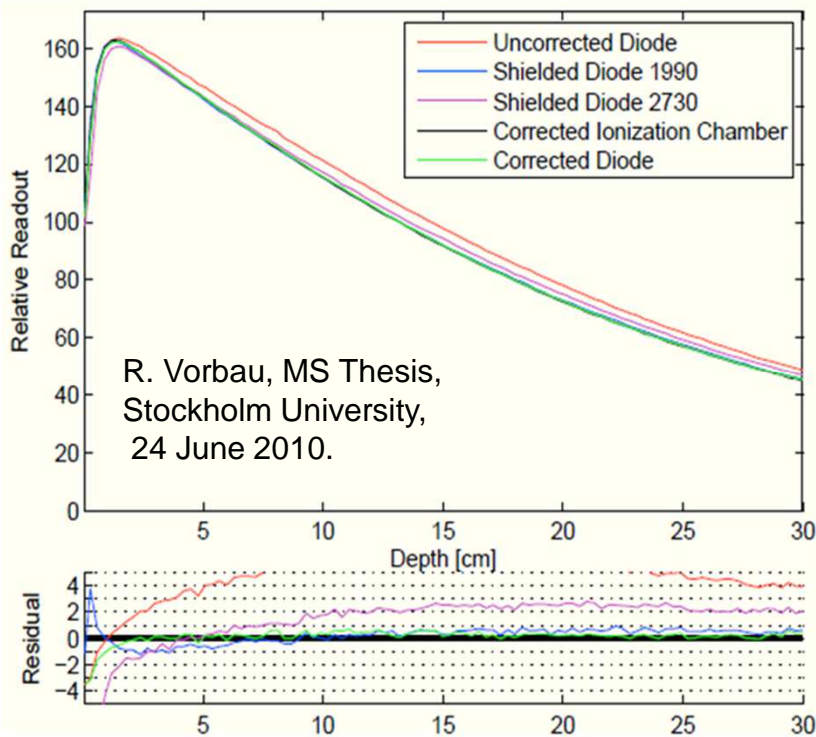
- no scattering from MLC;
- No beam divergency.

Based on pre-calculated MC pencil beams.

Eklund, K. & Ahnesjö, *Phys Med Biol* **54**, 6135 (2009).
Eklund, K. & Ahnesjö, A. *Med. Phys.* **37**, 6055 (2010).
Eklund, K. & Ahnesjö, A. *Phys. Med. Biol.* **55**, 7411–7423 (2010)
A. Ahnesjo et al, US 2009/0090870

Dosimetric performances (device specific)

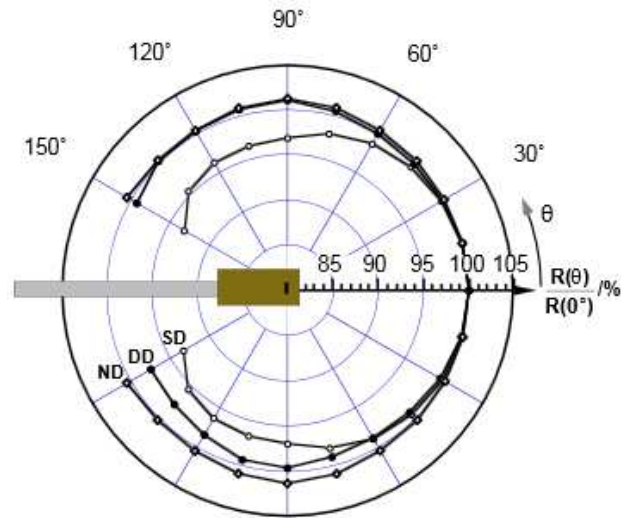
Energy dependence: software correction (I)



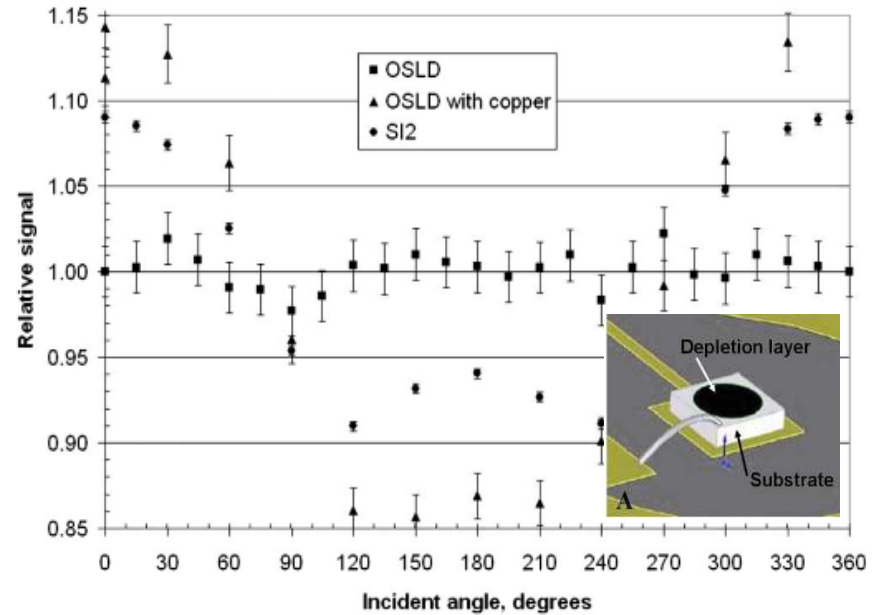
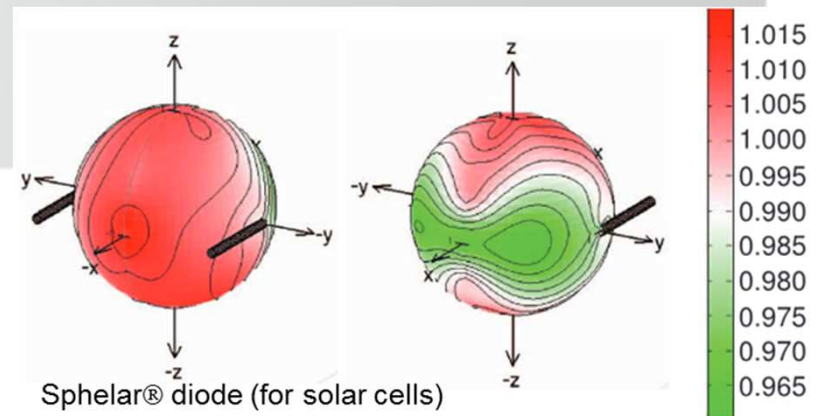
Dosimetric performances (device specific)

Angular dependence

Angular dependence is dominated by assembling
Almost no effect related to flat chip geometry

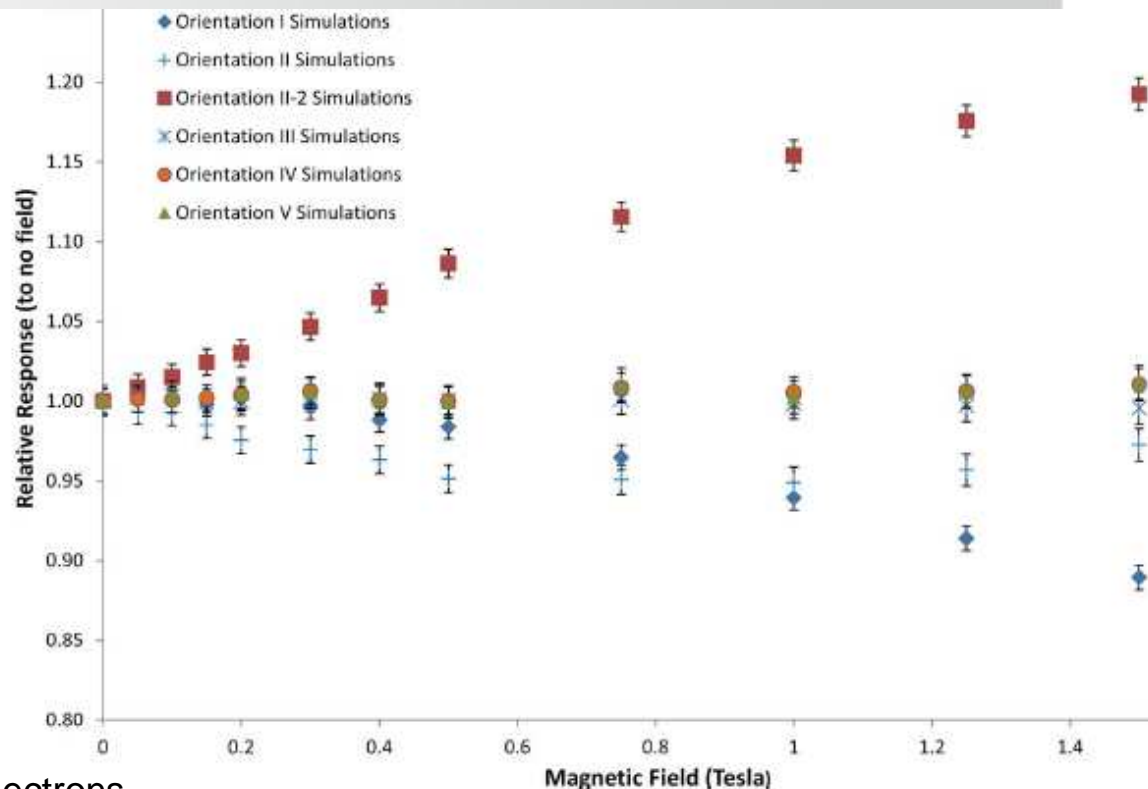
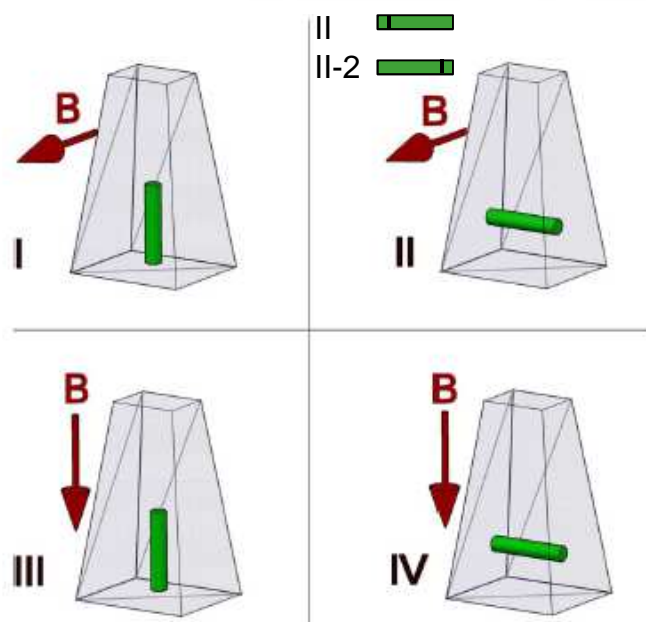


M. Westermark et al., Phys. Med. Biol. 45, 685, 2000.
P. Björk et al., Med. Phys. 27 (11), 2000
P. A. Jursinic, Med. Phys. 36 (6), 2171 (2009)
Barbés et al., Med. Phys. 41, 012102 (2014)



Dosimetric performances (device specific)

Performances in MRI LINACs



Dominant effect: bending of secondary electrons
 Almost no effect when **B** is parallel to beam axis.
 Need of correction if **B** is orthogonal to beam axis.

Dosimetric performances (device specific)

Small field dosimetry (I)

Very important applications (SBRT)

- Better treatment of some tumors
- Huge time and cost savings

Ideal for high resolution detectors

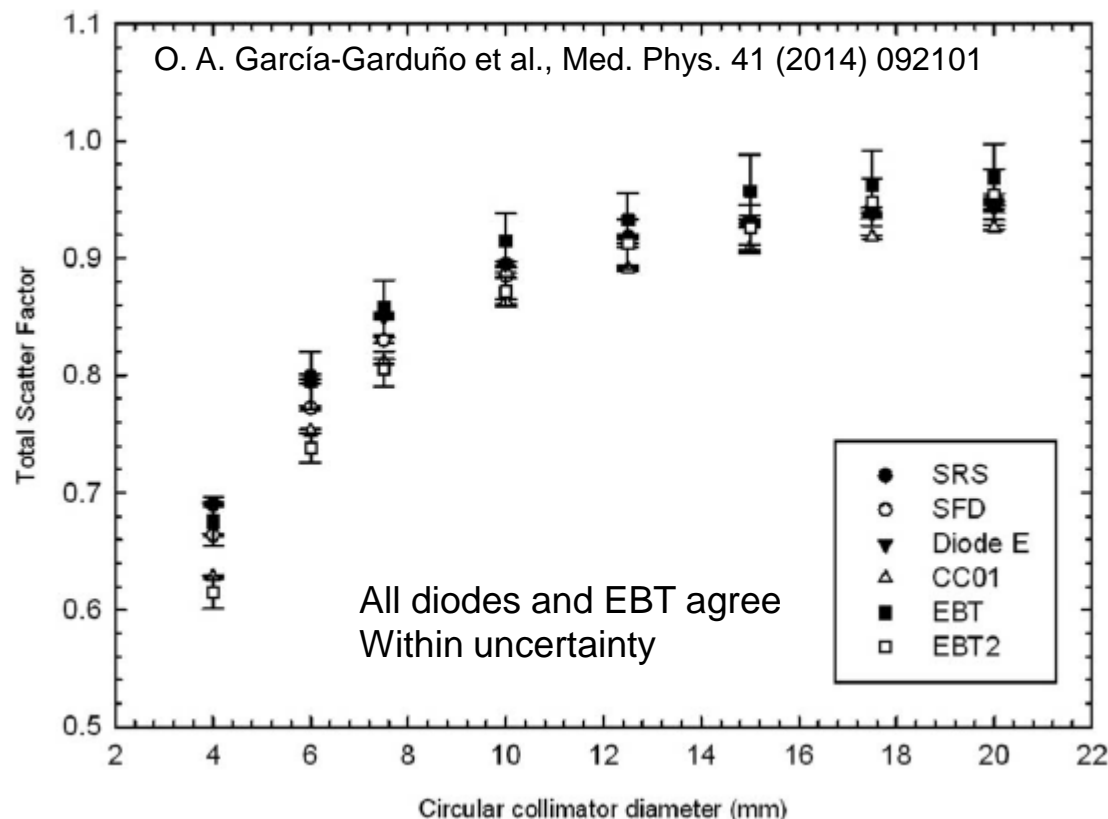
Specific features (below $2 \times 2 \text{cm}^2$):

- Lack of lateral charged particle equilibrium
- Obstruction of X-ray source
- Detector perturbation

Silicon promising...

few points to be clarified:

- a) How relevant is energy dependence?



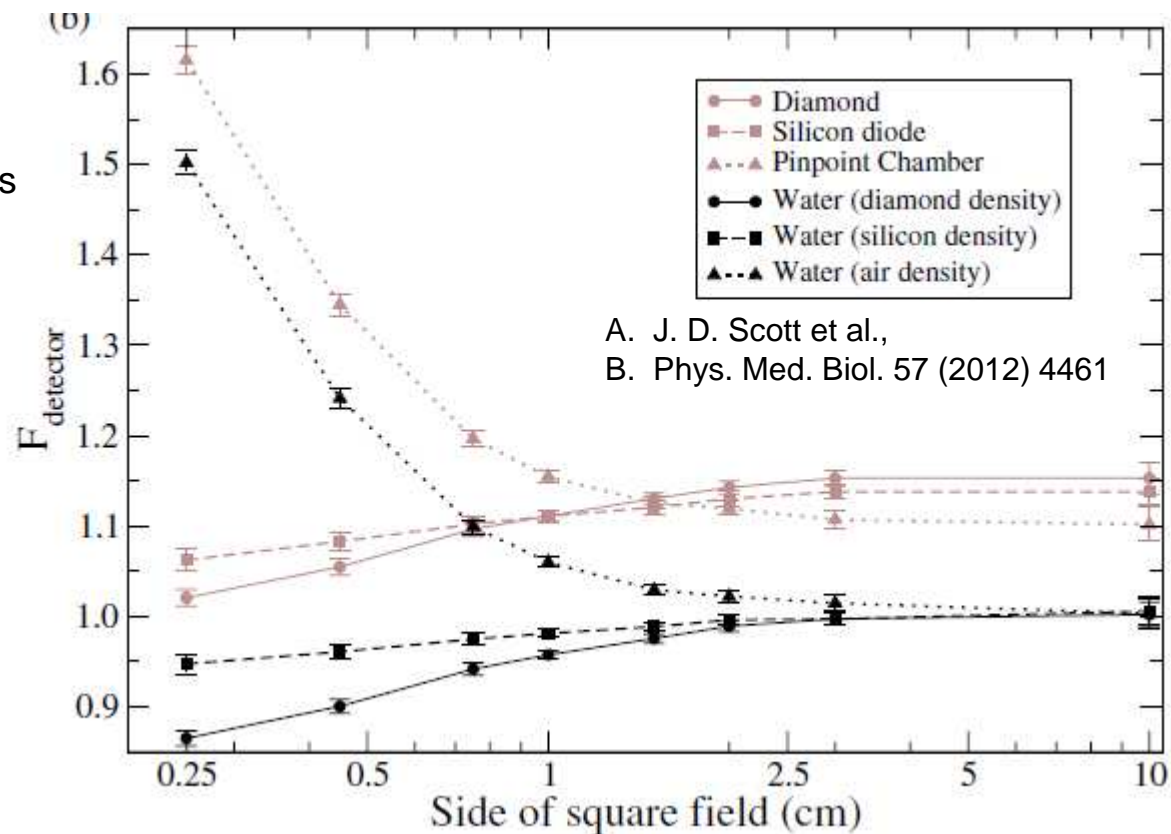
Dosimetric performances (device specific)

Small field dosimetry (II)

Silicon promising...

few points to be clarified:

- a) How relevant is energy dependence?
- b) Which physical parameters determines energy dependence (Z, density?)



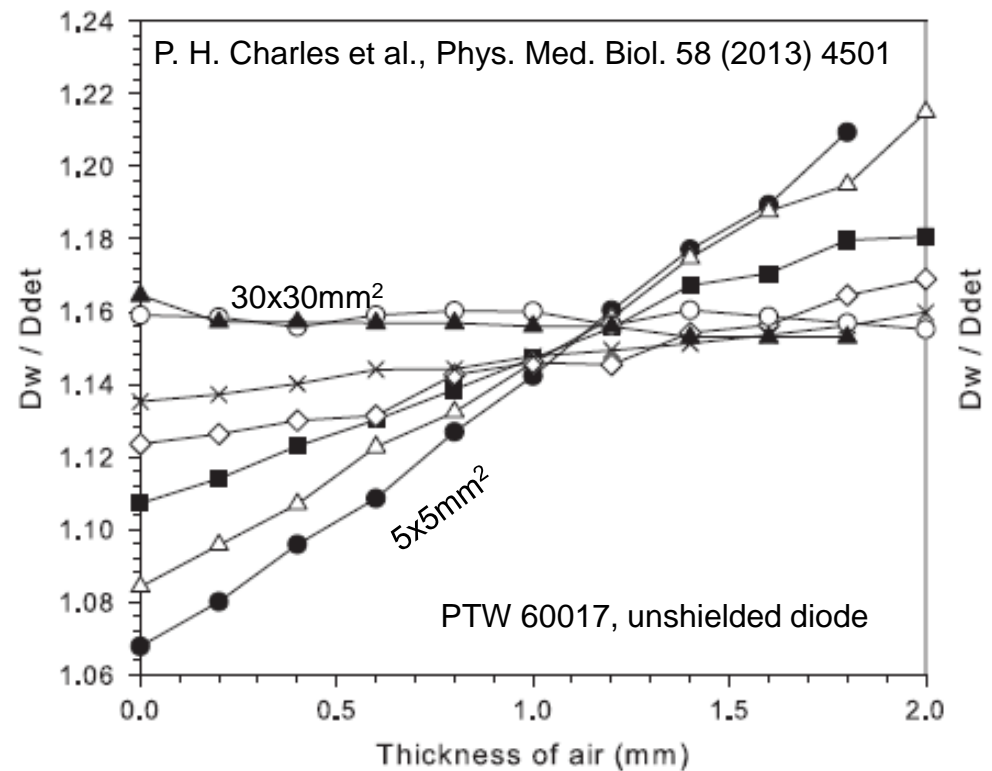
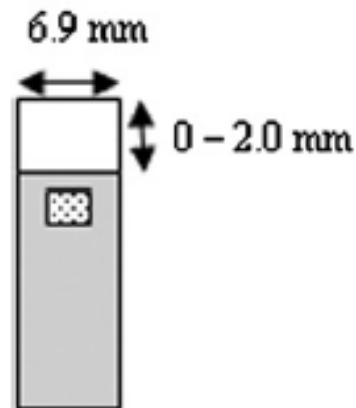
Dosimetric performances (device specific)

Small field dosimetry (III)

Silicon promising...

few points to be clarified:

- a) How relevant is energy dependence?
- b) Which physical parameters determines energy dependence (Z, density?)
- c) Improvement with inhomogeneities in assembling (e.g. air volumes)?



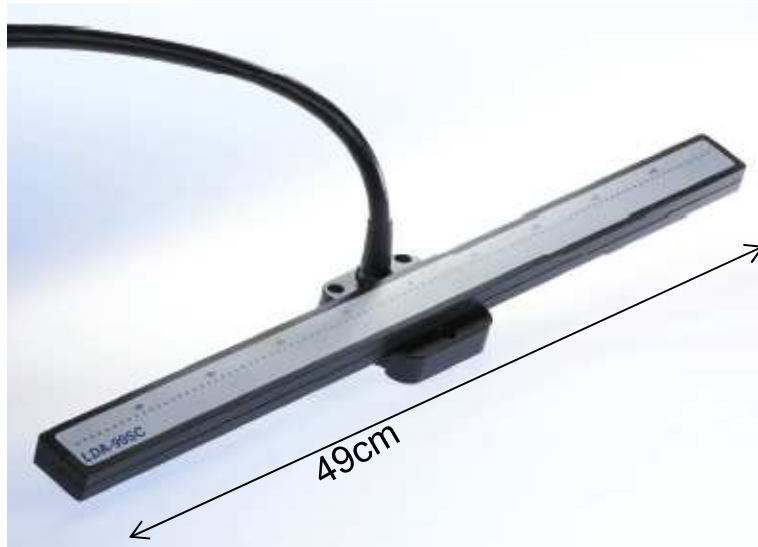
Part II

Diode arrays

- Commercial solutions
- Research prototypes

Commercial solutions

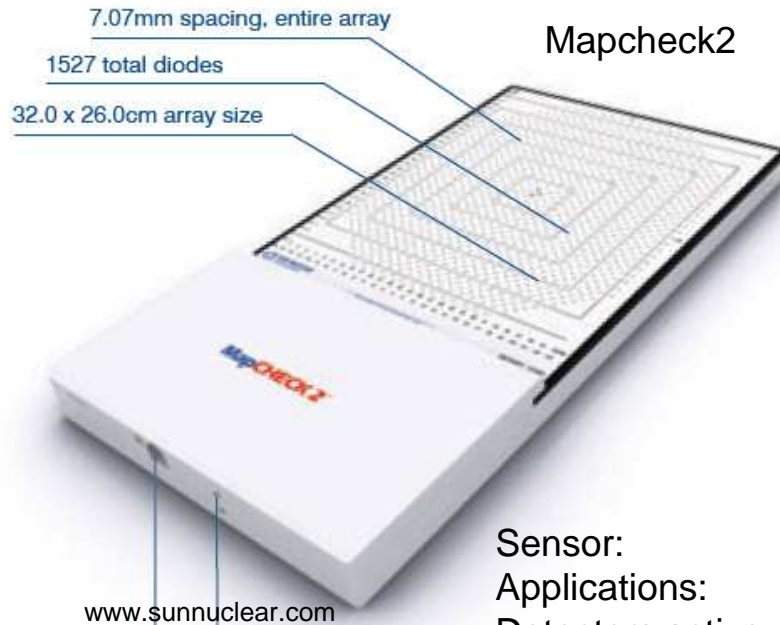
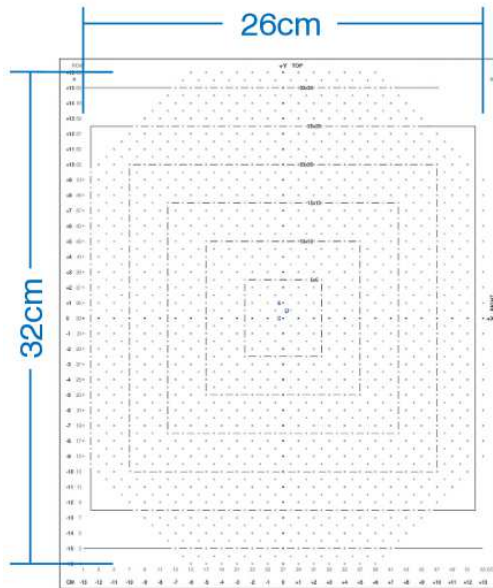
LINAC commissioning: LDA99 (IBA Dosimetry)



Sensor:	p-type diode, pre-irradiated;
Applications:	Relative dosimetry in a water phantom
Detectors active area:	3.1mm ² ;
Active volume:	0.15mm ³ ;
Sensitivity:	100nC/Gy;
Buildup:	~1mm

Commercial solutions

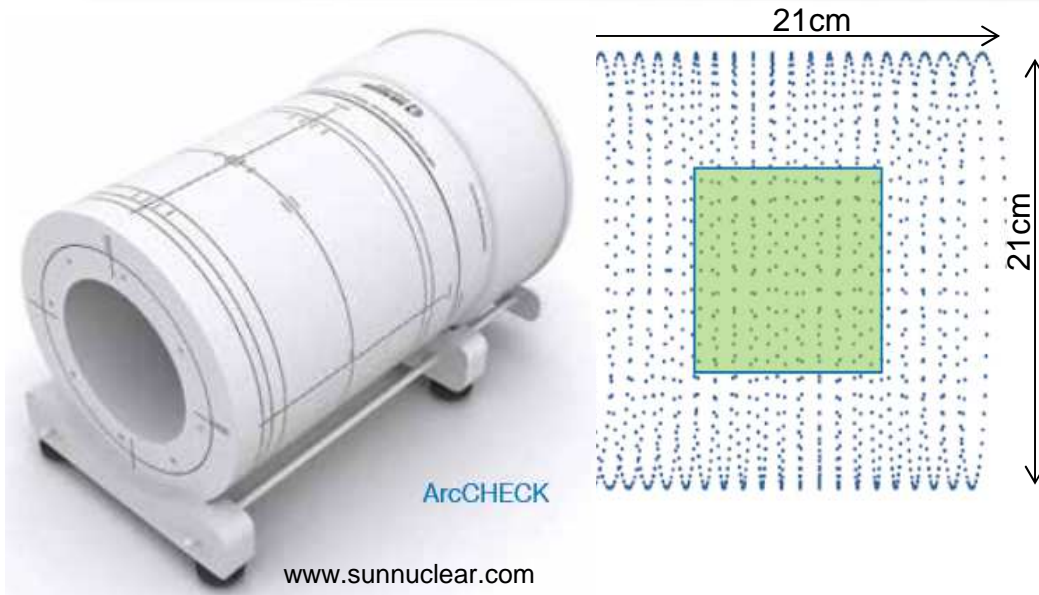
Multi purpose: MapCheck2 (Sun Nuclear)



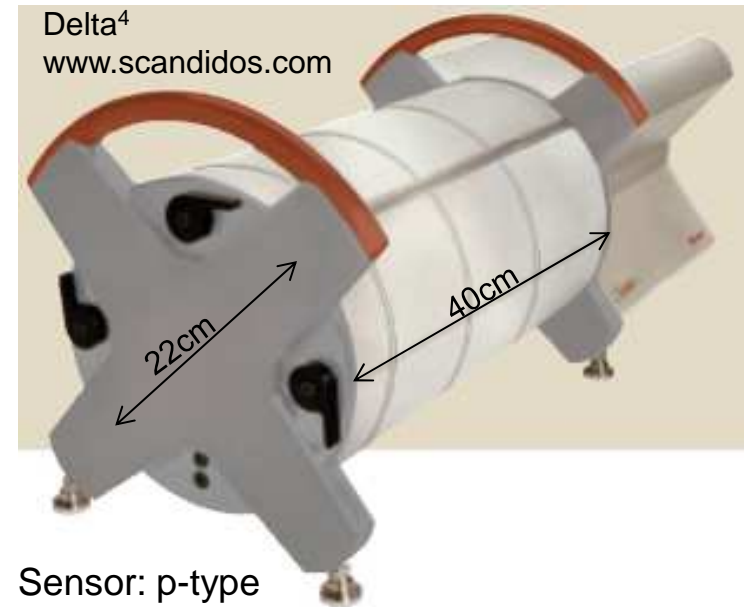
Sensor: n-type diode, Pt doped;
Applications: mostly plan QA
Detectors active area: 0.64mm²;
Active volume: 0.019mm³;
Sensitivity: 32nC/Gy;
Buildup: 2g/cm²

Commercial solutions

Patient plan QA: ArcCHECK (Sun), Delta⁴ (Scandidos)



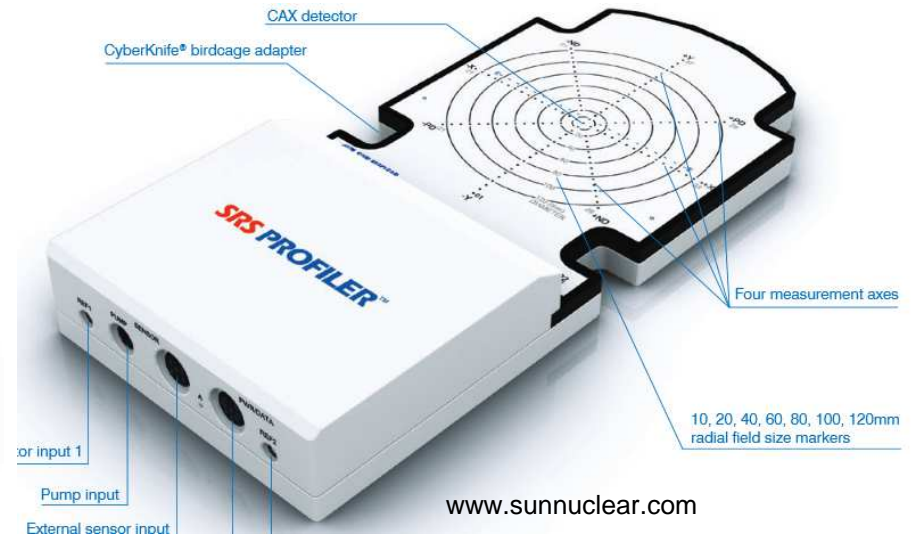
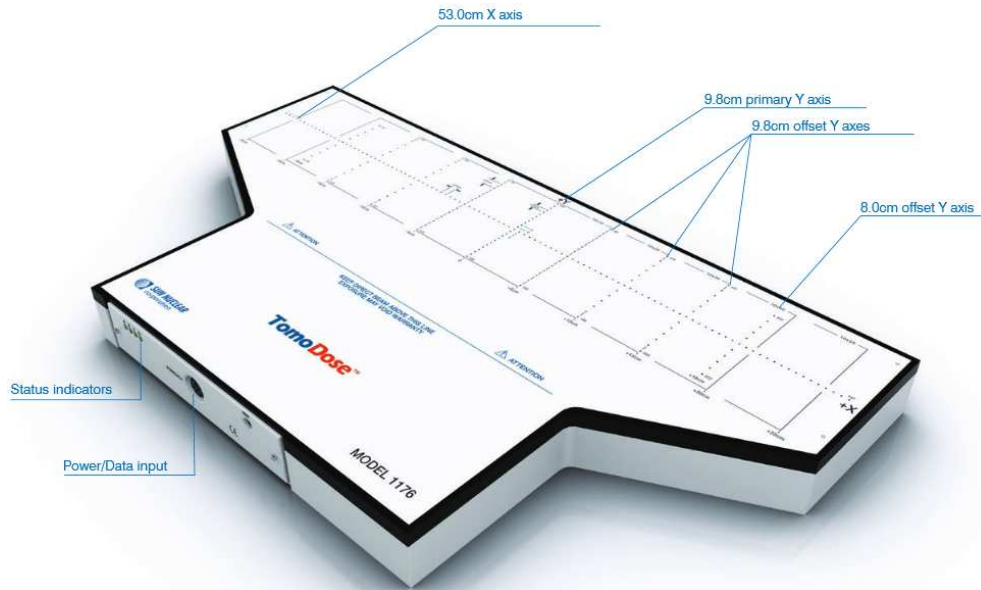
Sensor: same as MapCheck2
 Pixels: 1386
 Buildup: 3.3g/cm²



Sensor: p-type
 Pixels: 1069
 5-10 mm pitch (depending on region)
 detectors on two planes at 90°
 Active area 0.78mm²

Commercial solutions

LINAC QA: Tomo Dose and SRS profiler (Sun Nuclear)

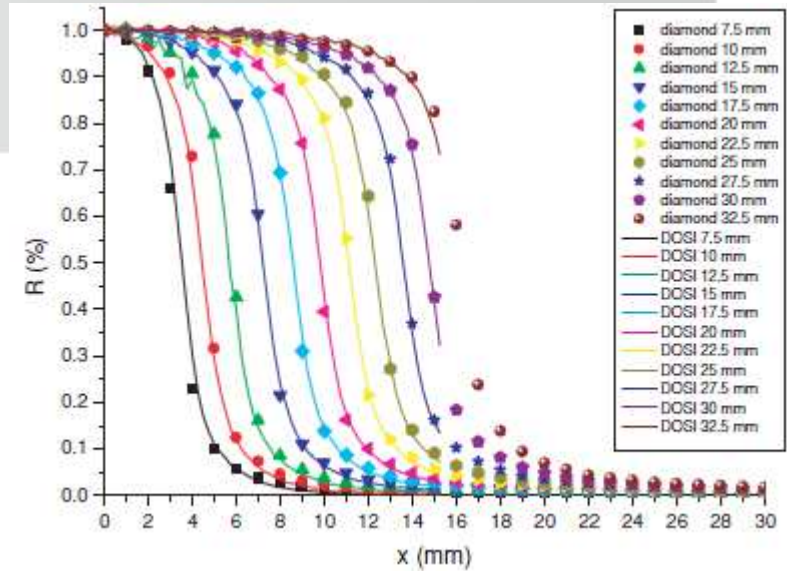


Sensor: same technology of MapCheck2;
 Application: specific for Tomotherapy
 Pixels: 223, 4-8mm pitch
 Buildup: 1.0g/cm²

Sensor: same technology of MapCheck2;
 Application: specific for CyberKnife
 Pixels: 125, 4mm pitch
 Buildup: 0.5g/cm²

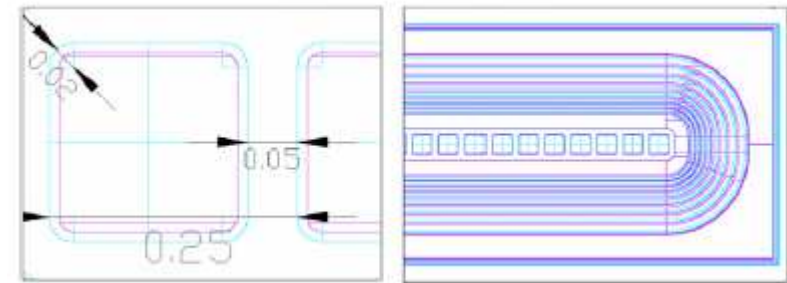
Research prototypes

Δ OSI



- First Si monolithic dosimeter
- Design mutated from high-energy physics
- N-type silicon, 1-10k Ω cm, 300 μ m thick.
- Readout based on X2CHIP integrator from RAL (UK)
- Detector is biased ($V_{rev}=20V$)

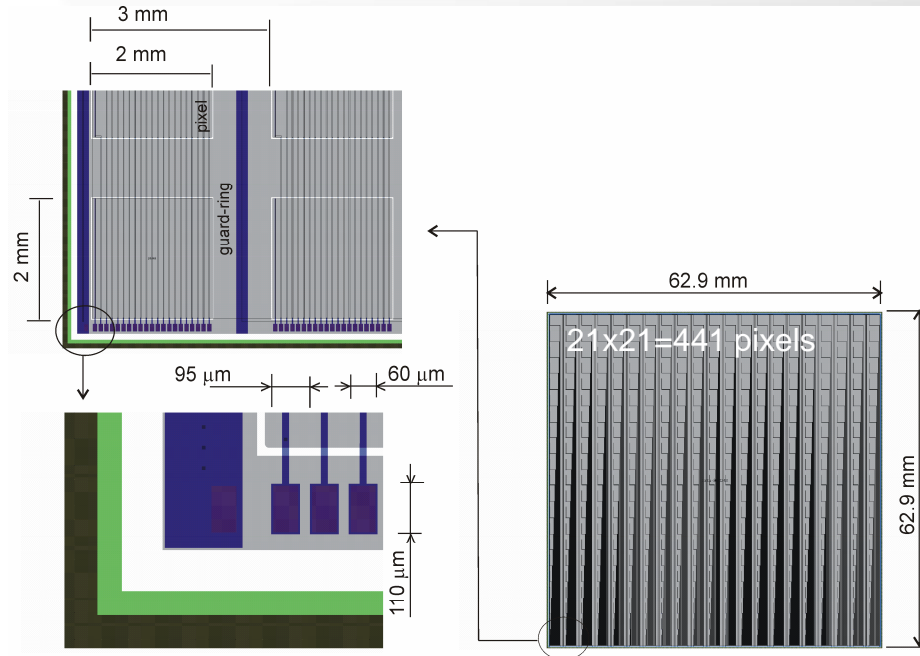
I. Redondo-Fernández et al., Nucl. Instr. Meth. A 563 (2006) 229.
 Manolopoulos, S. et al., Phys. Med. Biol. 54, 485 (2009).



128 diodes, 250 μ m pitch

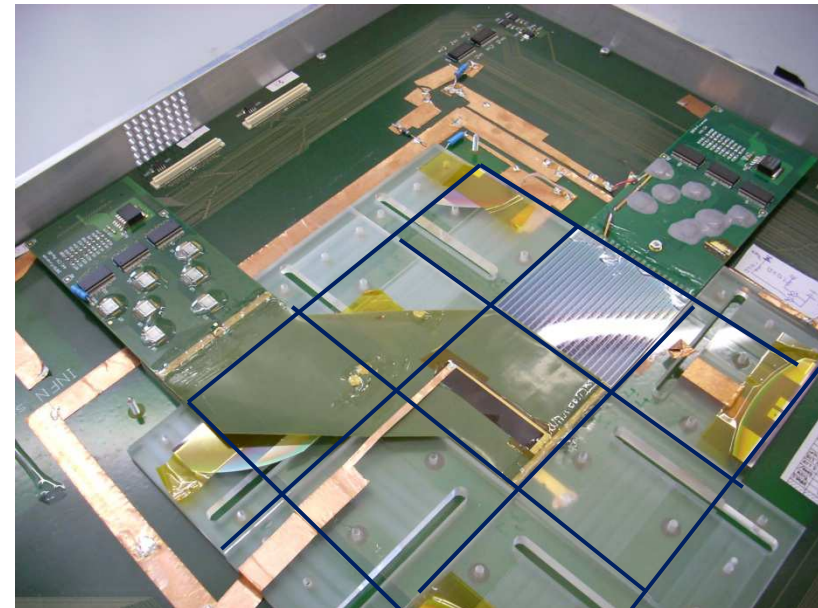
Research prototypes

„MAESTRO“ 2D array



Si Module:
p-type epitaxial diodes, 50 μm epi layer thickness
Overmetal strips to pads along one single side.
Diffused guardring structure.

- D. Menichelli et al., Nucl. Instr. and Meth. A, 583, 109 (2007)
- C. Talamonti et al., Nucl. Instr. and Meth. A., 583 (2007) 114
- C. Talamonti et al., Nucl. Instr. And Meth. A 658, 84 (2011)

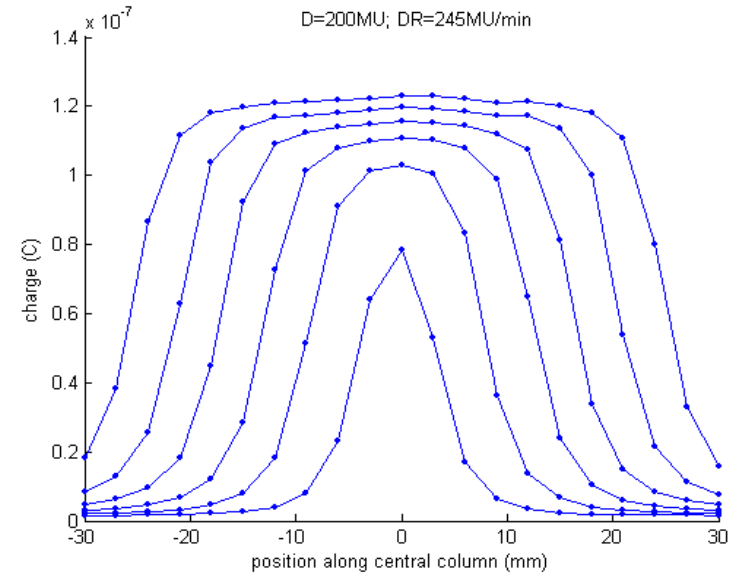
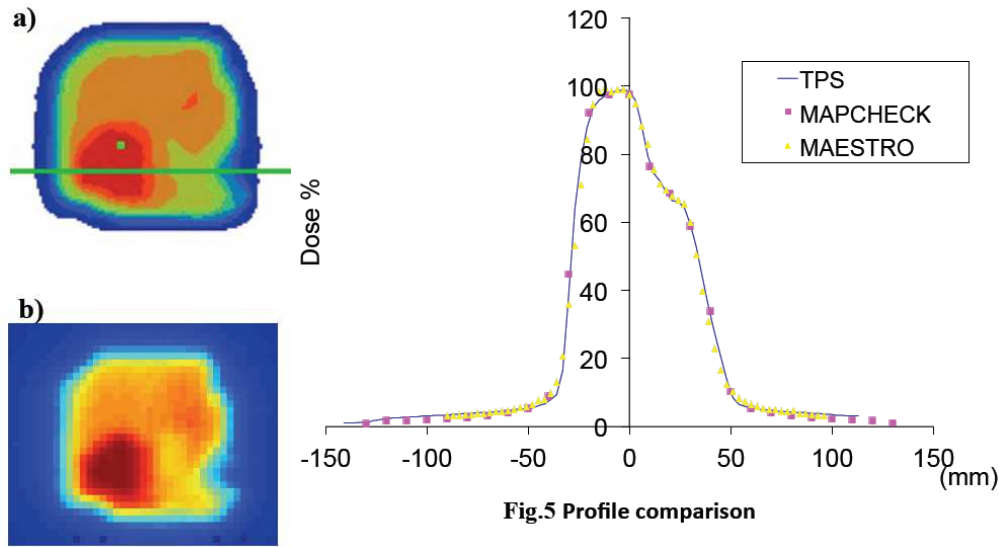


Assembled detector:
Up to 3x3=9 modules (19x19cm²)
TERA06 readout (INFN Turin)

Research prototypes

„MAESTRO“ 2D array

C. Talamonti et al., “2D Monolithic Epitaxial Silicon Detector for Application in Radiotherapy,” presented at RESMDD 2012, Florence, 10-12 October 2012.



IMRT beam, 6MV

6MV, profiles of squared fields
(0.8-4.8cm size)

Research prototypes

„Dose magnifying glass“

P-type silicon

$\rho=5\text{k}\Omega\text{cm}$ (FZ), $10\ \Omega\text{cm}$ (CZK)

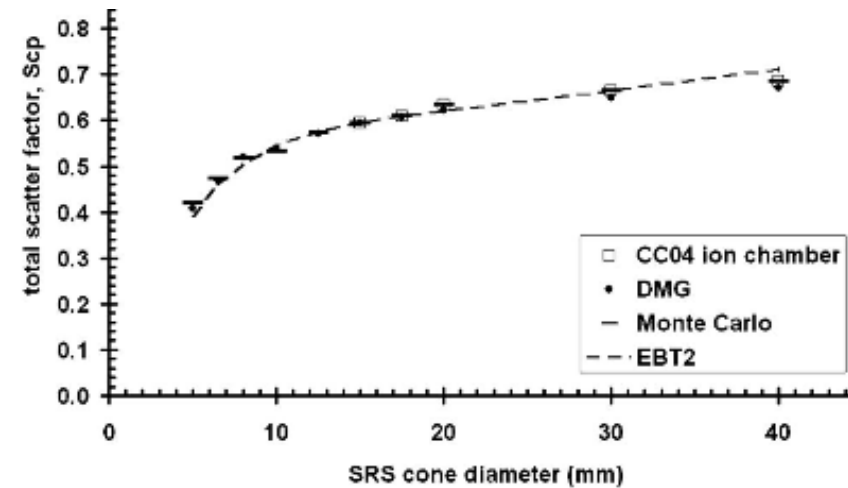
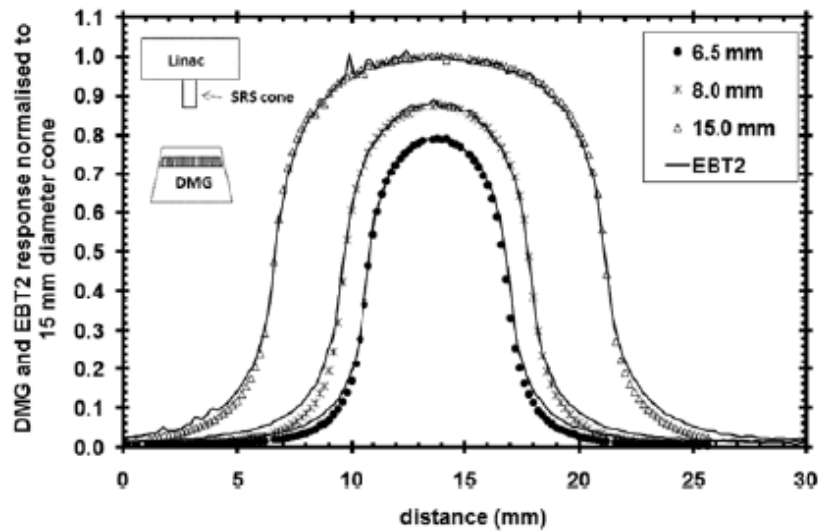
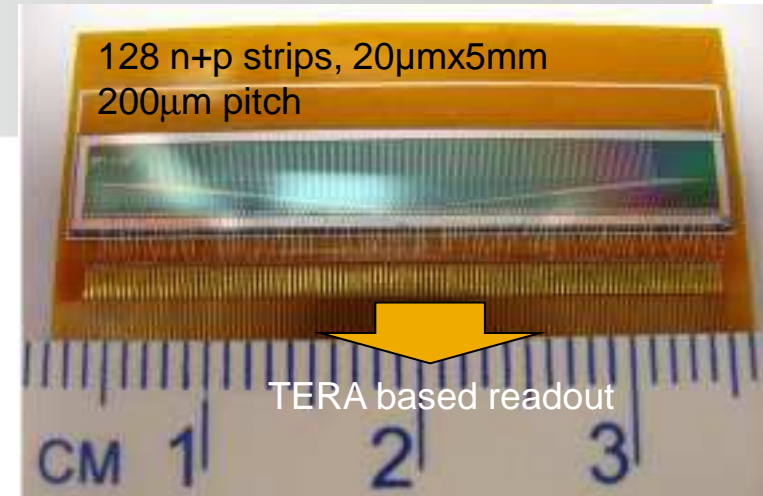
375 μm thickness

Pre-irr: 15kGy (1MeV e^-)

J. H. D. Wong et al., Med. Phys. 37 (2) 2010, 428.

J. H. D. Wong et al., Med. Phys. 38 (3), 2011, 1226.

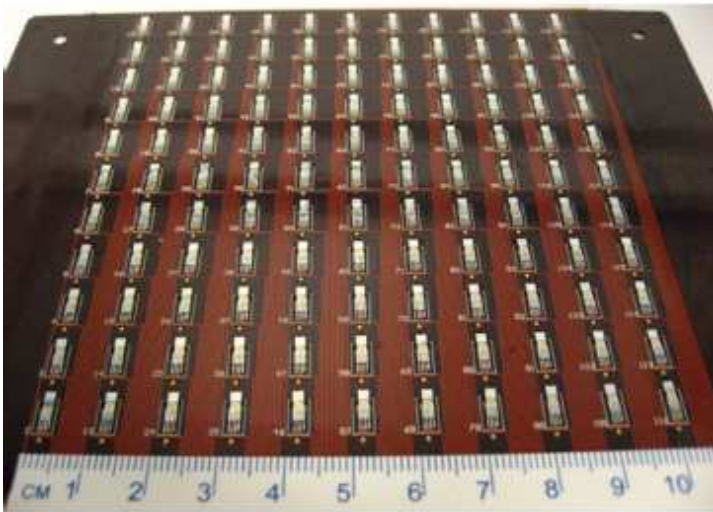
J. H. D. Wong et al., Rad. Meas. 46 (2011) 1615.



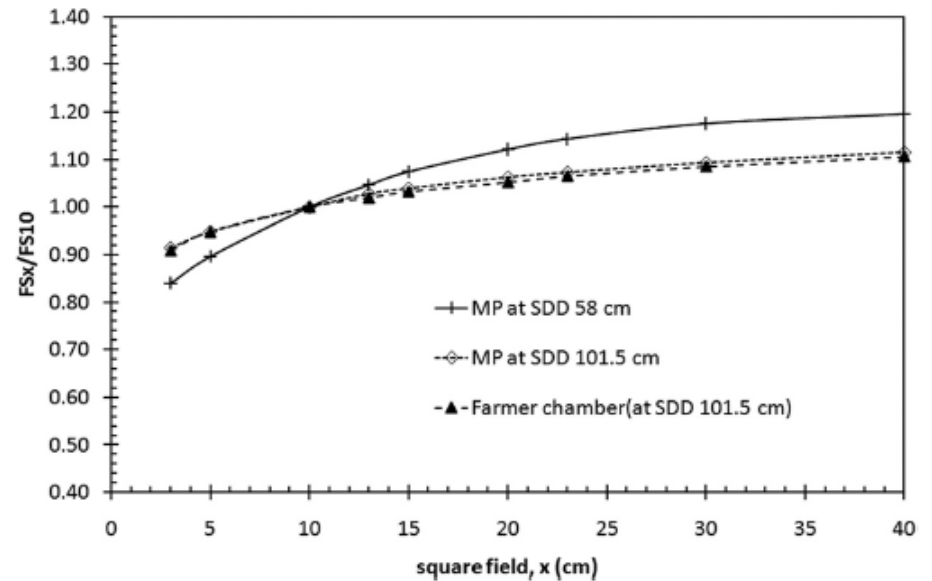
Research prototypes

„Magic Plate“ (Wollongong)

J. H. D. Wong et al., Med. Phys. 39 (5) 2012, 2544.
US2010/0164534 A1



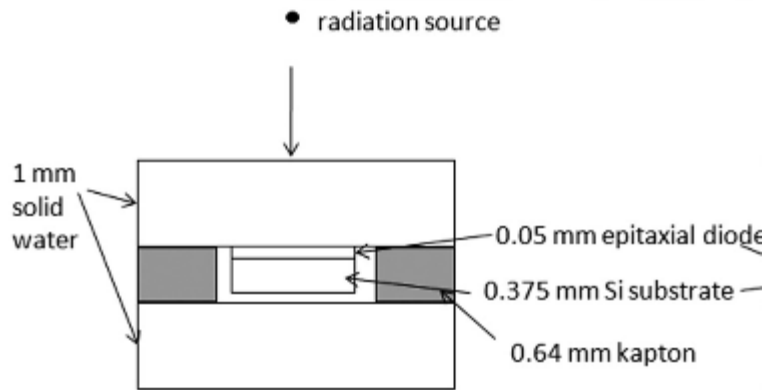
11x11 single diodes
P-type (100 Ω cm), 50 μ m epi layer
0.5x0.5mm² active area
Pre-irradiation: 1.3kGy (6MV)+40kGy (⁶⁰Co)



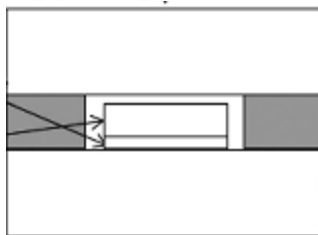
Transmission or phantom detector mode
Chips embedded in thin plastic/kapton layers
(proprietary technology)
1 cm pitch

Research prototypes

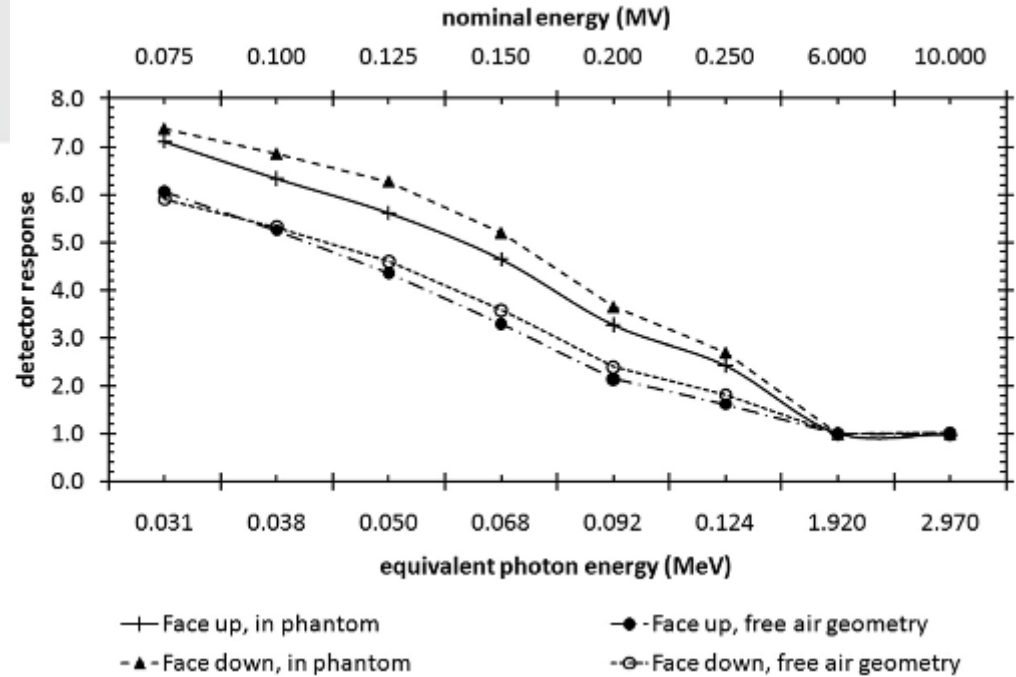
„Magic Plate“- encapsulation



(a) Face up



(b) Face down configuration



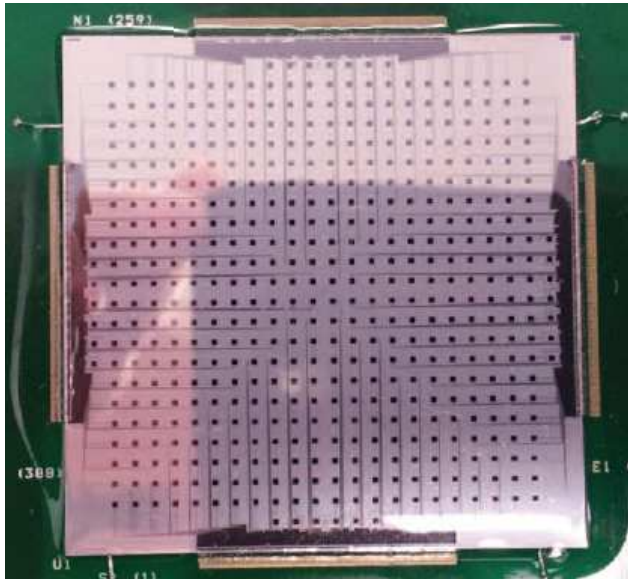
Problem:

- Tight buildup (no lack of electronic equilibrium)
- No damage to Si, no scratches, no mechanical stress
- No additional energy dependence

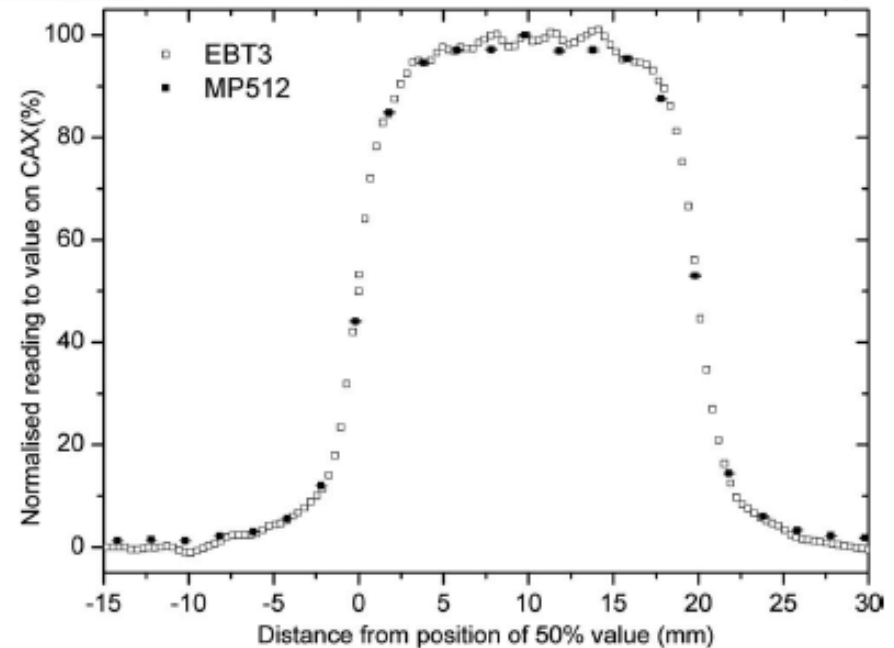
Research prototypes

„Magic Plate-512“

A. H. Aldosari, Med. Phys., 41, 091707 (2014).



Monolithic Array,
Bulk p-type substrate
 ^{60}Co pre-irradiation
Readout based on Texas AFE0064
Mounted on flexible FR4, PMMA buildup



22x22 pixels,
0.5x0.5cm² pixel active area
52x52mm² area
2mm pitch

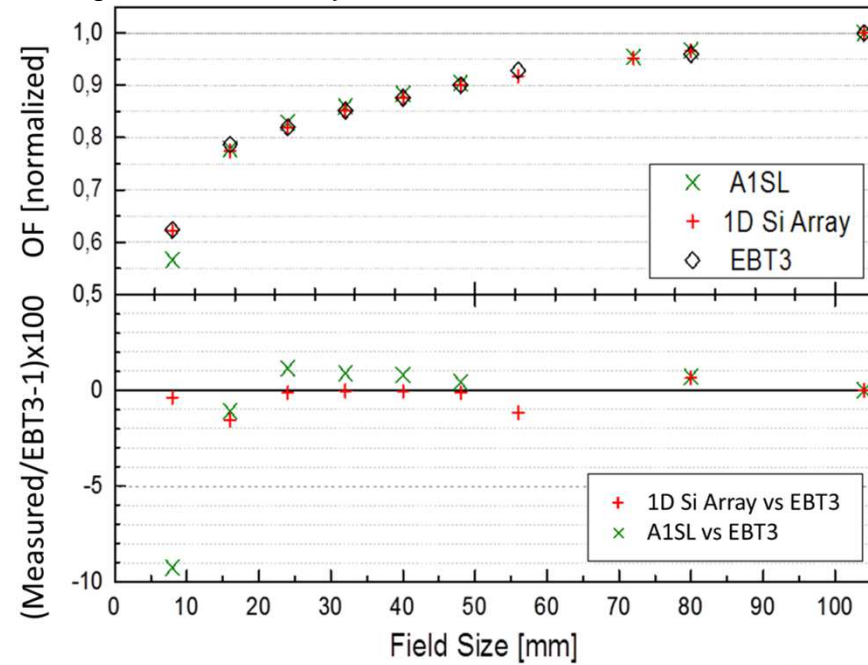
Research prototypes

IBA „1D Si Array“



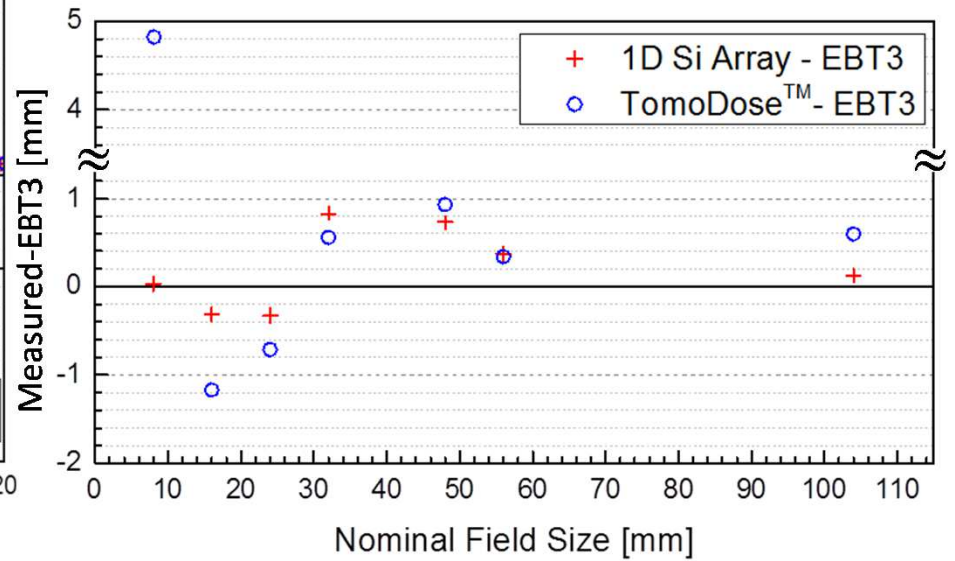
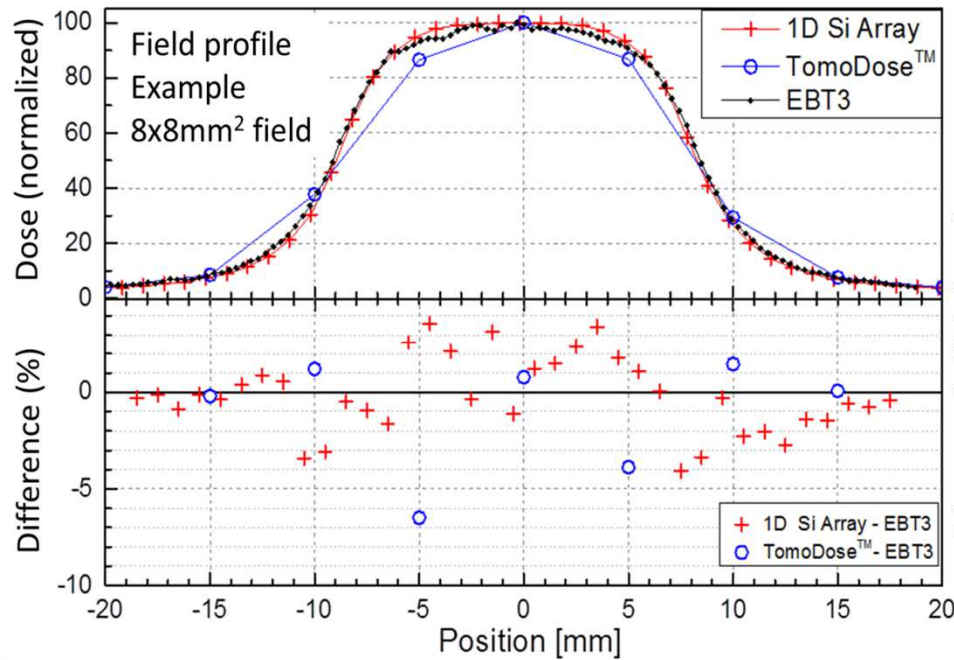
24cm active length, 1mm pitch
Assembling of 64 pixels monolithic modules
Connected to „Zebra“ electrometer with a
multi-pole shielded cable.

C. Talamonti et al., „Novel Silicon Array for quality assurance in photon and proton therapy,“ AAPM annual congress, Austin, July 2014.



Research prototypes

IBA „1D Si Array“



Part III

Final remarks and future perspectives

- State of the art
- Semiconductor design
- System design
- Competing technologies*

*Huge bibliography; I can provide references about specific issues to the interested persons

Remarks and perspectives

State of the art summary

Present situation

- Solutions available to manufacture high performances Si dosimeters
- Consolidated readout scheme: photovoltaic, DC coupling, current integration, no bias
- Single diodes are widely used for scanning, in-vivo and OF measurements (small fields)
- Commercial Arrays (of single diodes) cover most applications but in-vivo (ScandiDos solution announced).
- Current research: mainly exploiting high spatial resolution (typically with monolithic array)
- Multichannel electrometers with ADC are available (e.g. INFN Tera0x, TI and Analog...)

Open issues

- Energy dependence
 - large fields ($>10 \times 10 \text{cm}^2$): photoelectric effect;
 - very small fields ($<1 \times 1 \text{cm}^2$) : unclear.
- Best use of high resolution possibilities offered by Si processing
 - Trade off between area coverage, pixel pitch, cost, readout complexity

Remarks and perspectives

Semiconductor design

Diodes shall be radiation hard (recipes exist)

- Low dS/dD , to preserve calibration (a user calibration procedure must be given!);
- Low dose rate dependence (especially with unflattened beams)
- Quantum noise may be not negligible if pixels are very small (important for small fields).
- Angular and energy dependence shall be faced at system level.

Monolithic arrays or single diodes?

- Monolithic chips are convenient only if full area coverage is required;
- Monolithic: better uniformity; assembling is only conceptually easier.
- Array of single diodes cost effective if pitch is not too small, depending on assembling technology

If monolithic, which module size?

- ❖ Few full wafers? Many small chips? A tradeoff is needed.
- ❖ Large area chips are fascinating but: lower yield, huge replacement costs.
- ❖ Attention to important axes (central axes covered with 3x3, not with 2x2...)
- ❖ Fan out is not obvious...

Final remarks and perspectives

System design

General rule

One shall have in mind the final application, and a consistent feedback from clinics!

Assembling

- No energy dependence worsenign (minimal amount of high-Z materials, especially upstream)
- Scattered photon shielding: may be a problem for electrons and small fields
- Mechanical stability, even with temperature changes
- No damage to chips (e.g. scratches)

Readout complexity

- Parallel readout needed by diodes (multiplexing available only with MAPS)
- Number of readout ICs and costs rise with #pixels
- Critical for 2D applications: $\#pixels \propto (1/pitch)^2$, $\#pixels \propto (\text{detector size})^2$
- Integrating IC cannot be placed inside clinical radiation field (parasitic signal generation)
- Reliability and power consumption are worsened by high complexity

Final remarks and perspectives

Competing technologies (already commercialized)

Air filled ionization chambers

- „Gold standard“ (highest dosimetric performances)
- E.g. IBA MatriXX and StarTreck, Sun IC Profiler, PTW Octavius 1500 and 729
- 7-10mm pitch, prototypes down to 3.5mm
- No cost problems in covering large surfaces

a:Si flat panels: (software for LINAC-embedded Epid)

- Large area (up to 40x40cm²) and high resolution (200µm) thanks to a:Si deposition and multiplexing.
- Pretty expensive, radiation hardness not completely clear, few manufactures.
- Indirect detection (aim is imaging), need software correction
- EPIdose (Sun), EpiGray (Dosisoft), Dosimetry Check (Math Resolution), Epidos products
- Research about stand alone devices

Liquid filled ionization chambers (e.g. PTW Octavius SRS)

- Better spatial resolutions due to higher sensitivity (2.5mm available)
- „Gold standard“ attribute of air is lost;
- Problems with dose per pulse and stability

Scintillating detectors, coupled with cameras (e.g. IBA Lynx for protons)

- Prototypes developed for photons (including scintillating liquids/gel)

Final remarks and perspectives

Competing technologies (research stage)

Monolithic Active Pixel Sensors (MAPS)

- Crystalline silicon equivalent of a:Si flat panel
- Potentially more performing
- A lot of reasearch, no commercial applications.
- Size limited by cost and wafer size

Arrays of scintillating fibers, or of fibers coupled with scintillators

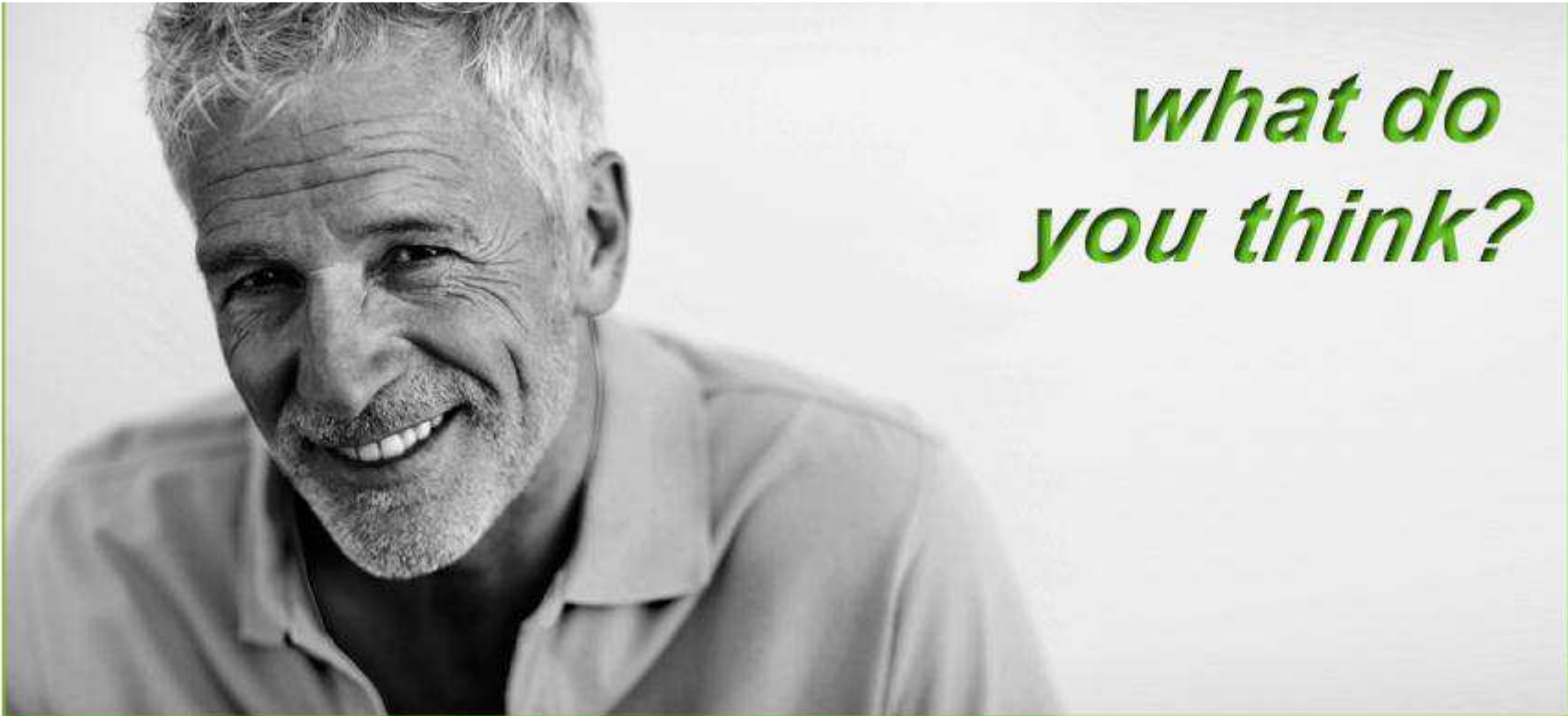
- Readout with cameras, photodiodes or PMT

GEM detectors,

- Usually coupled with pads or scintillator/optical systems
- Mainly proposed for proton- and hadron-therapy, or medical imaging.
- Few experiments with photons; advantages are unclear.

Diamond arrays

- Experiments with monolithic poly-crystalline diamond (to reduce cost) arrays
- Is diamond really better performing with small fields (which are the case of interest)?



*what do
you think?*

Thank you

Iba